

IEEE SW Test Workshop

Semiconductor Wafer Test Workshop



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**Contacting various metal compositions
using ViProbe[®] Vertical Technology**

June 6 to 9, 2010
San Diego, CA USA

Content

- Motivation.
- ViProbe® Vertical Probe Technology.
- CRES Measurement setup.
- Evaluation Results Al, Au, Cu Pad.
- ViProbe® Temperature Probe @ 200°C.
- ViProbe® ADC Testing in Probe to Data Sheet specifications.
- Conclusions.
- Future Work.



Motivation.

ViProbe[®] Vertical Probe Technology.

CRES Measurement setup.

Evaluation Results Al, Au, Cu Pad.

ViProbe[®] Temperature Probe @ 200'C.

ViProbe[®] ADC Testing in Probe to Data Sheet specifications.

Conclusions.

Future Work.



Motivation

- **Minimum pad deformation post sort required for,**
 - Die shipping direct to customer (automotive).
 - FCOL (Flip Chip on Lead) Bumping process.
 - OPM (Over Pad Metallisation) Assembly process.
- **Multiple 'contact pad' metal compositions,**
 - Al, Au, Cu.
- **Multi-site Sort >8 sites / Grid Array Pattern.**
 - EWLP (Embedded Wafer Level Package).
 - WLCSP (Minus bump).



Motivation (Cont.)

- **Temperature Sort of products used in,**
 - Automotive,
 - Industrial applications.
- **KGD (Data Sheet Specifications) with any combinations of the above.**
- **Increased requirement for Vertical Probe Technologies.**
 - Minimum pad deformation, Stable CRES.



Motivation.

ViProbe[®] Vertical Probe Technology.

CRES Measurement setup.

Evaluation Results Al, Au, Cu Pad.

ViProbe[®] Temperature Probe @ 200'C.

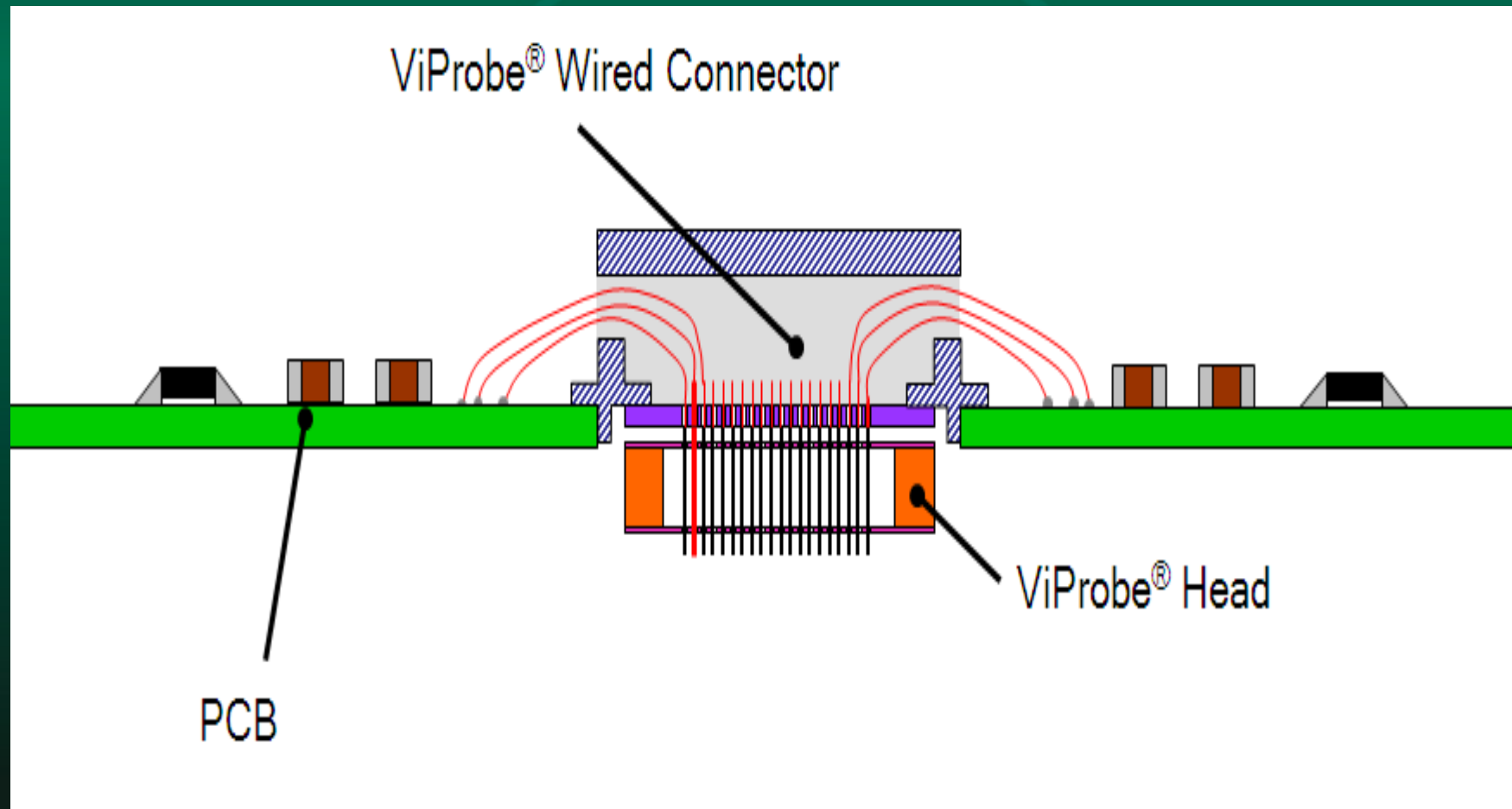
ViProbe[®] ADC Testing in Probe to Data Sheet specifications.

Conclusions.

Future Work.



ViProbe® Vertical Probe Technology.

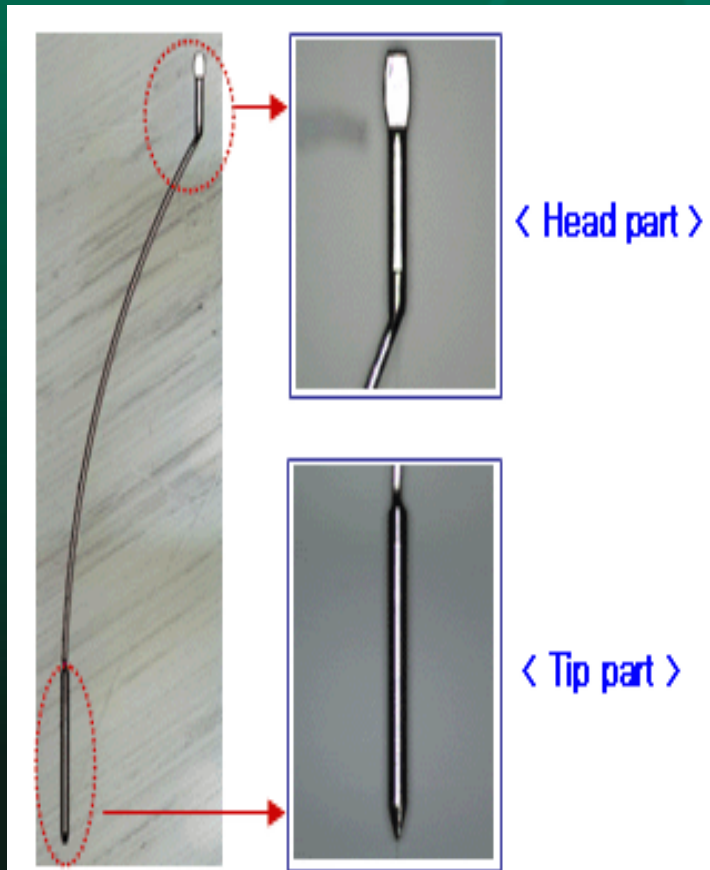


- **Feinmetall ViProbe® Wired Series**
- Same construction / needle tip for WLCSP, Al, Au, Cu Pad.



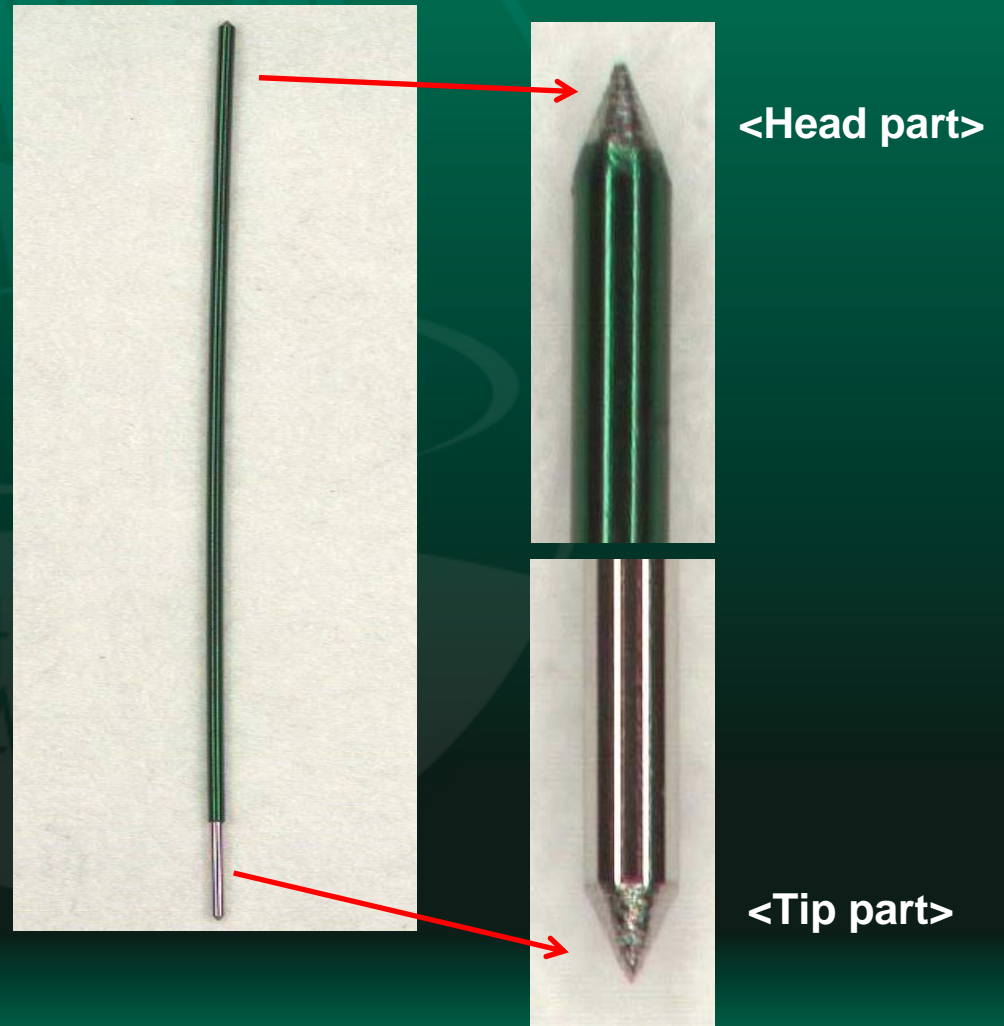
ViProbe® Vertical Probe Technology.

'Cobra' style Needle

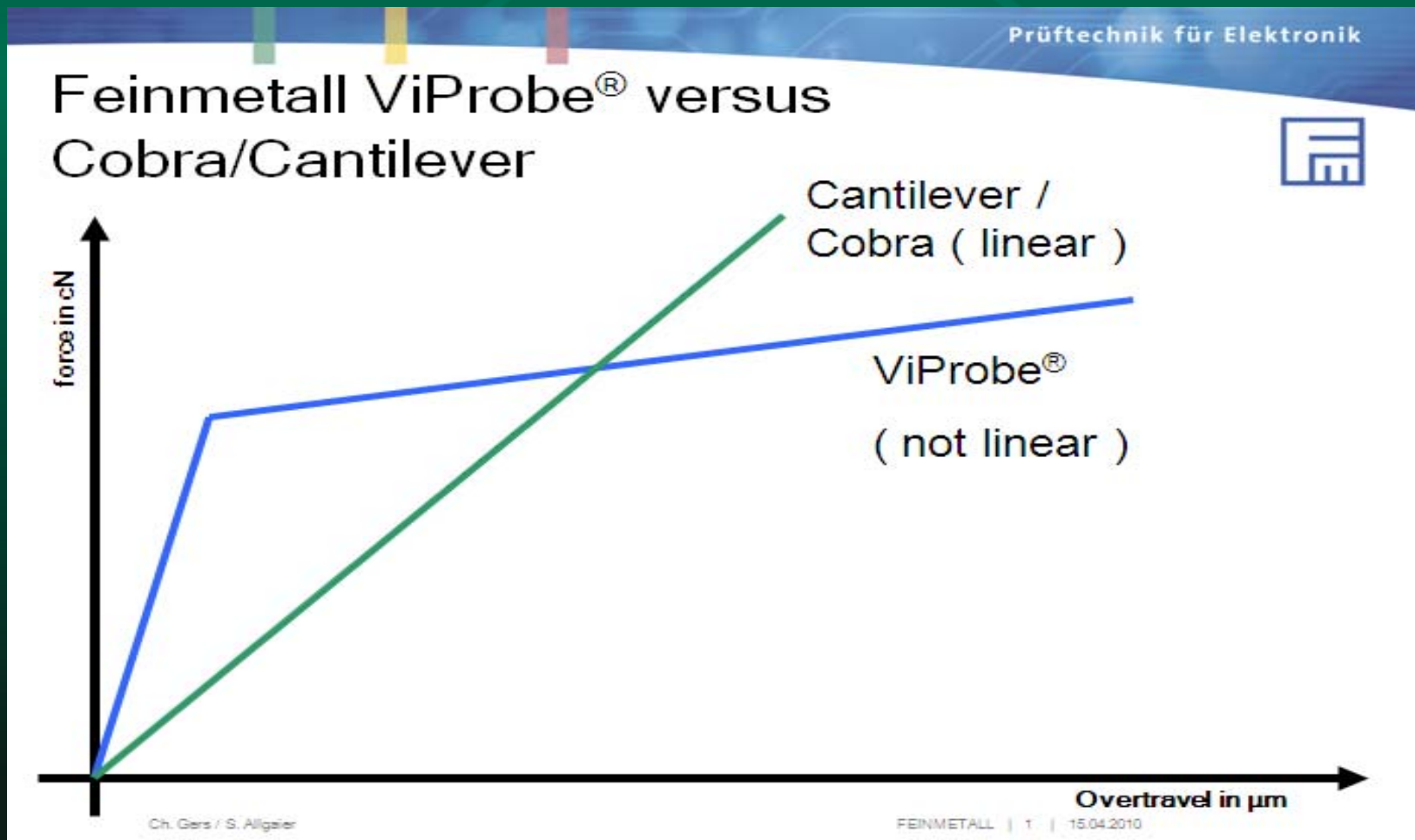


http://www.probein.com/vertical_needles_e.aspx

ViProbe® Beam



ViProbe[®] Vertical Probe Technology.



- ViProbe[®] a safer technology than Cantilever where probe mark area and scrub depth need to be controlled.



ViProbe[®] Advantages

- Mechanically robust and reliable.
- Consistent probe mark signature across full array.
- Easily repaired, minimum downtime.
- Same ViProbe[®] Beam used for contacting WLCSP Solder bump, Al / Au / Cu Pad.
- ViProbe[®] improvements (innovation development from Feinmetall) keeping pace with customer requirements.



Motivation.

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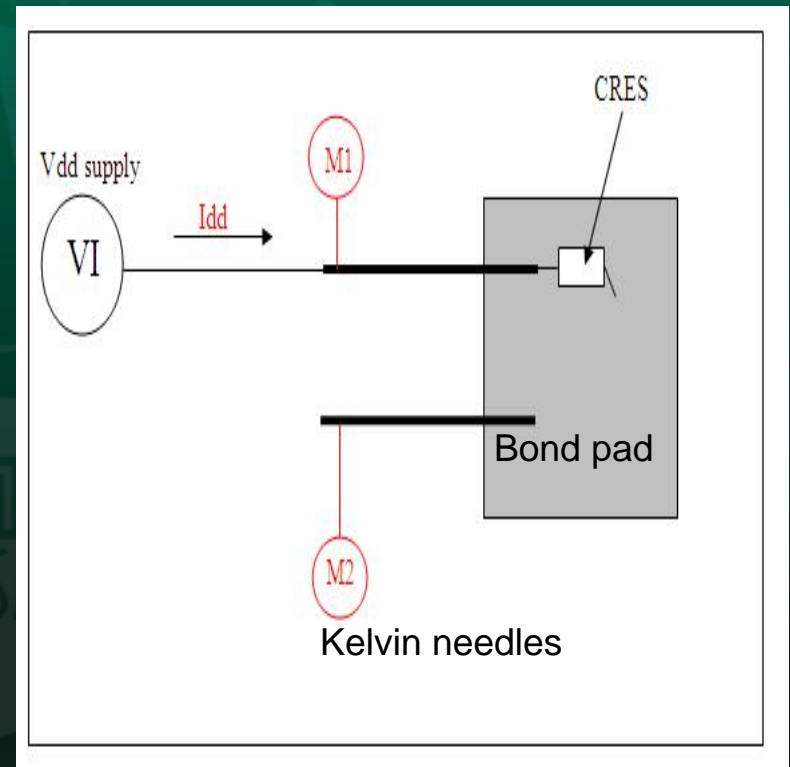


CRES Measurement Setup.

- Method 1: Measure CRES as part of Production Sort.

Requirements

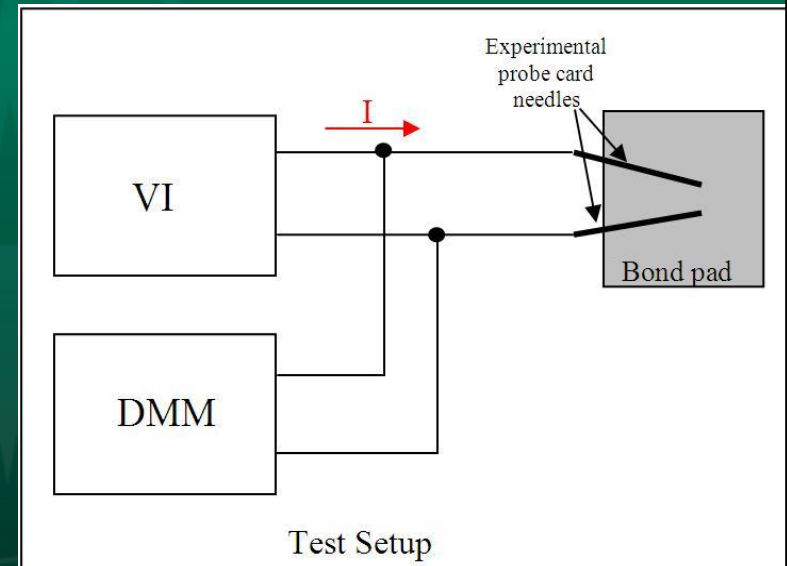
- A pad large enough for a Kelvin contact (Force & Sense).
- Preferably a supply pin.
- PIB board design must include CRES measurement capability.
- $CRES = (V_{m1} - V_{m2}) / I_{dd}$



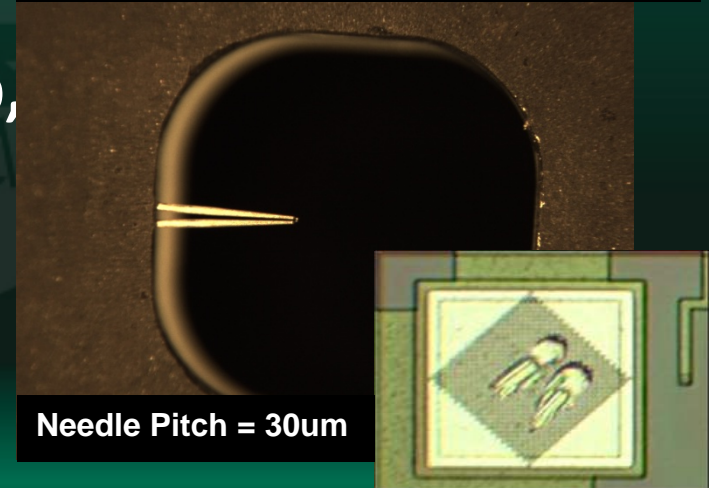
CRES Measurement Setup.

Method 2: “CRES Test Jig”

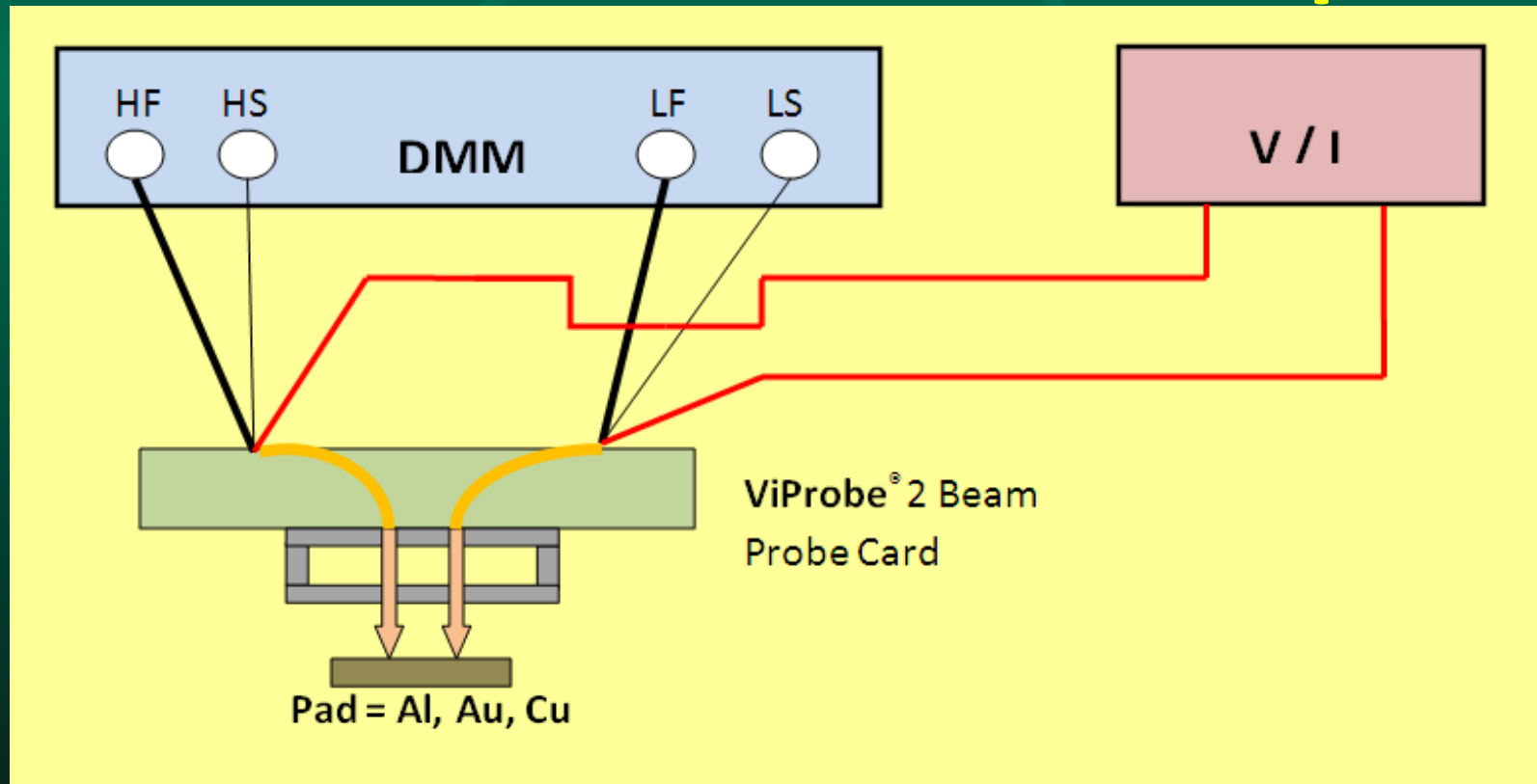
- Offline CRES measurement.
- “CRES Test Jig”
 - A 2 Needle Probe Card.
 - CRES PIB connected to DMM & VI.
- Enables CRES experiments and capability to optimize Sort setup, debug yield hits.



Cantilever CRES probe card & scrub mark



CRES Measurement Setup.



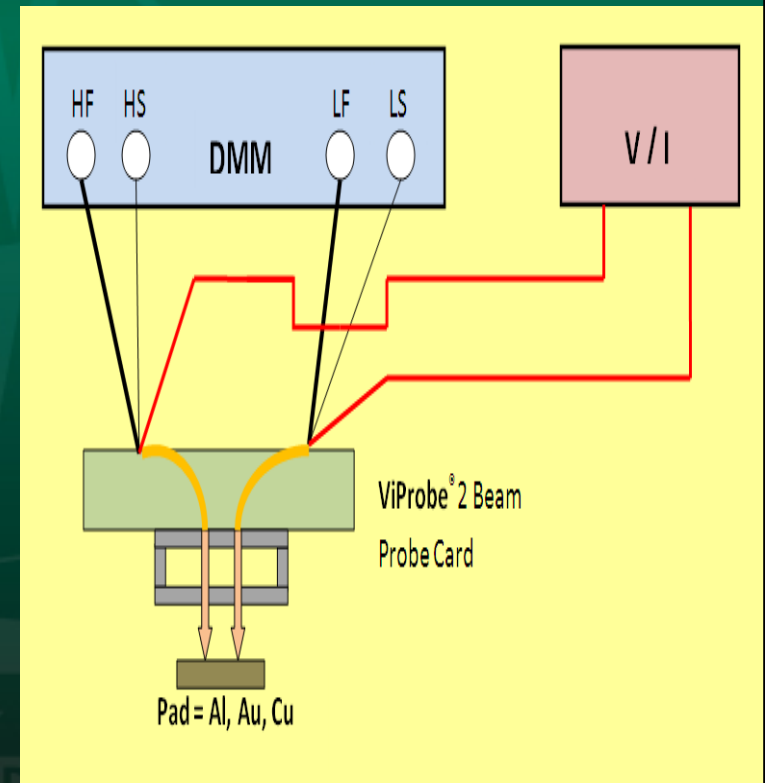
- **CRES Test Jig (ViProbe[®] 2 Beam Probe Card)**
 - **2 Mil Beams (Trivar HC[®] pointed tip),**
 - **75 μ M Pitch.**



CRES Measurement Setup.

- **Experiment Steps (CRES Test Jig),**

1. Touchdown on Pad 1 on Die 1,
2. Measure CRES with DMM (1mA),
3. Force current ($i = 30\text{mA}$),
4. Measure CRES with DMM (1mA),
5. Index to Pad 1 next die,



- Probe Pad 1 all Die,
- Re-probe at Pad 1 with X,Y, offset,
Or change to Pad 2

Motivation.

ViProbe[®] Vertical Probe Technology.

CRES Measurement setup.

Evaluation Results Al, Au, Cu Pad.

ViProbe[®] Temperature Probe @ 200'C.

ViProbe[®] ADC Testing in Probe to Data Sheet specifications.

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Future Work.



Evaluation Results Al, Au, Cu Pad.

- Post Sort with ViProbe[®] Vertical Technology,
Measurements / Analysis from,
 - (1) 2D Probe Mark inspection (Leica Microscope),
 - (2) 2D Probe Mark inspection (NSX 105),
 - (3) 3D Probe Mark inspection (Zygo Profilometer),
 - (4) CRES.

NOTE:

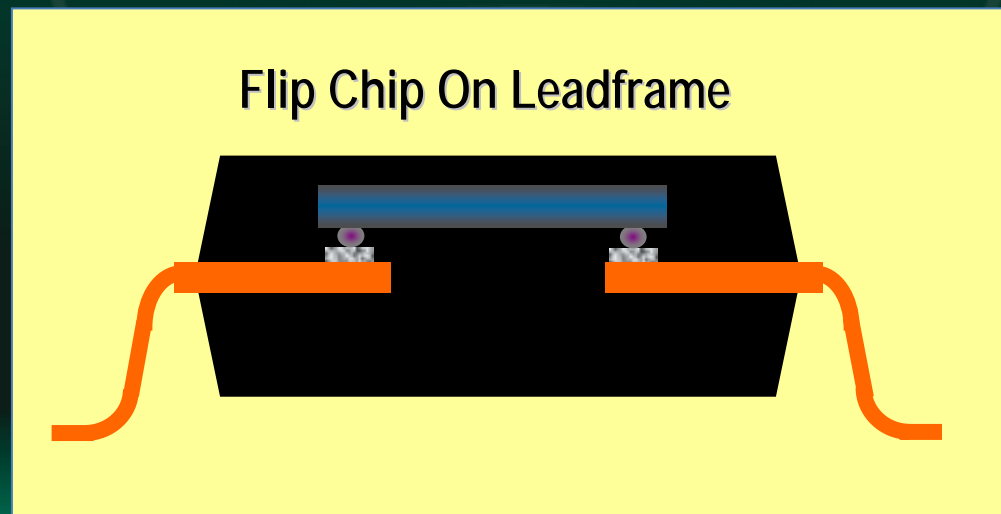
(1) to (3) above PMI measurements taken after Sort with full ViProbe[®] Production Probe Cards.

(4) Using CRES JIG using ViProbe[®] 2 Beam Probe Card.



ViProbe[®] on Al Pad.

- Flip Chip on Lead (FCOL) requires Sort before bumping.
 - Electroplated bump process requires smallest possible probe mark.
 - ViProbe[®] was qualified to probe Al Pad (FCOL parts) before electroplated bump process.



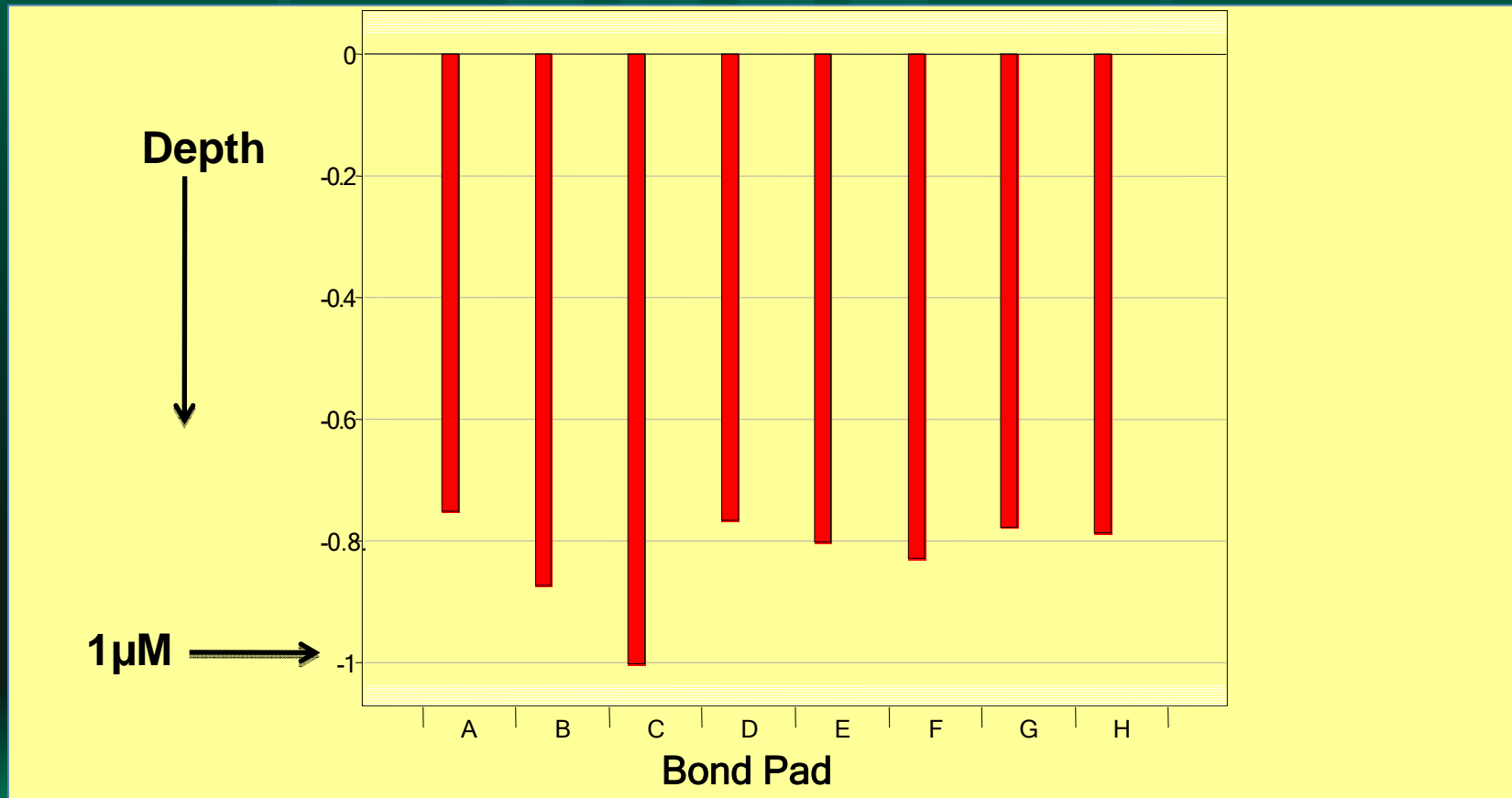
ViProbe[®] on Al Pad.

- Automotive KGD, 3 Temperature pass (Ambient, -40'C, +160'C).
- Critical Quality parameters,
 - Probe Mark Size,
 - No Pad edge incursions.



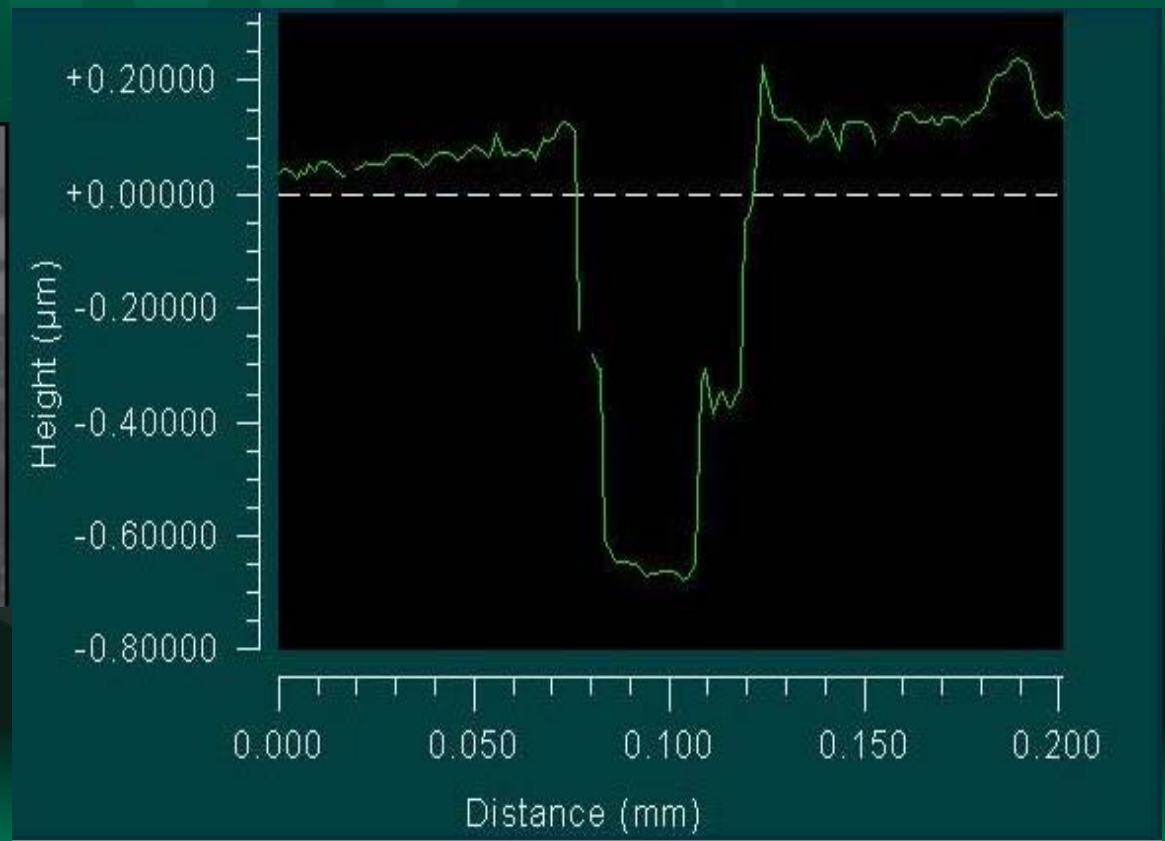
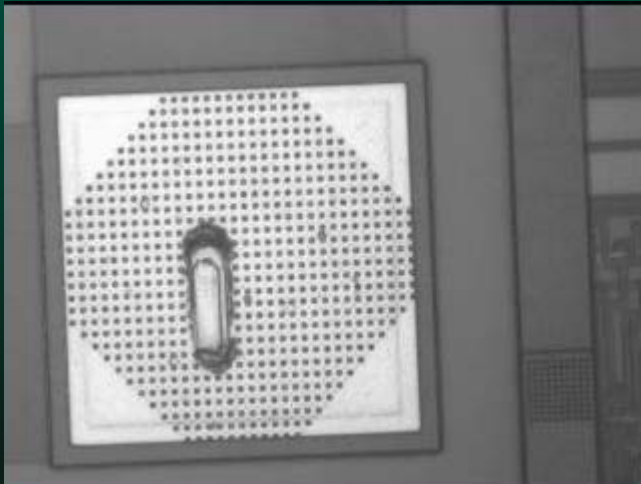
ViProbe[®] on Al Pad.

- Al Pad deformation post Cantilever Sort.
 - Zygo Profilometer (2007 Data).
 - Typical Scrub depth $0.8\mu\text{M}$.



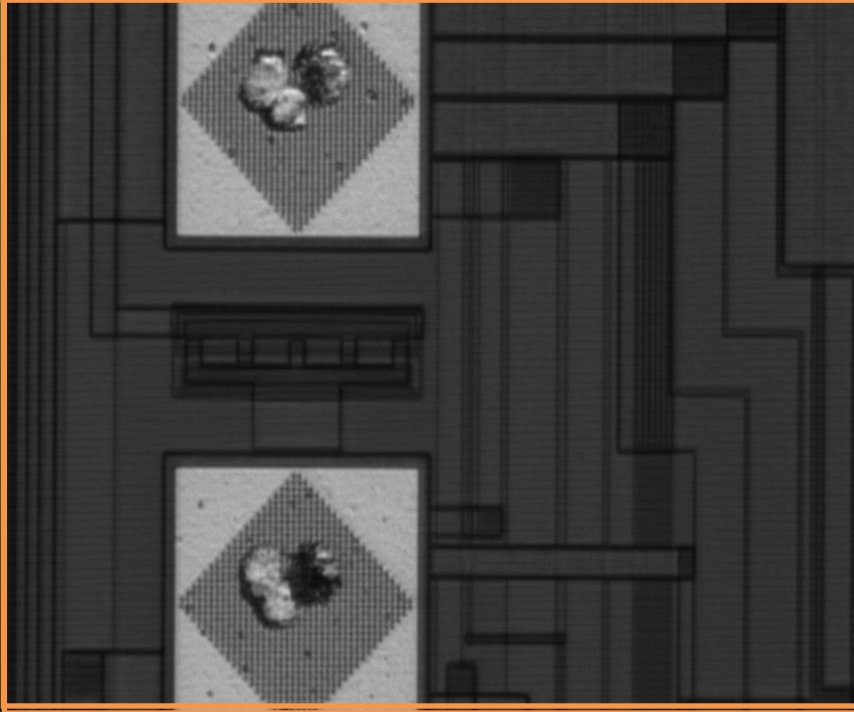
ViProbe[®] on Al Pad.

- Zygo Profilometer.
- Depth of Cantilever on Al Pad = $0.7\mu\text{M}$.



ViProbe[®] on Al Pad.

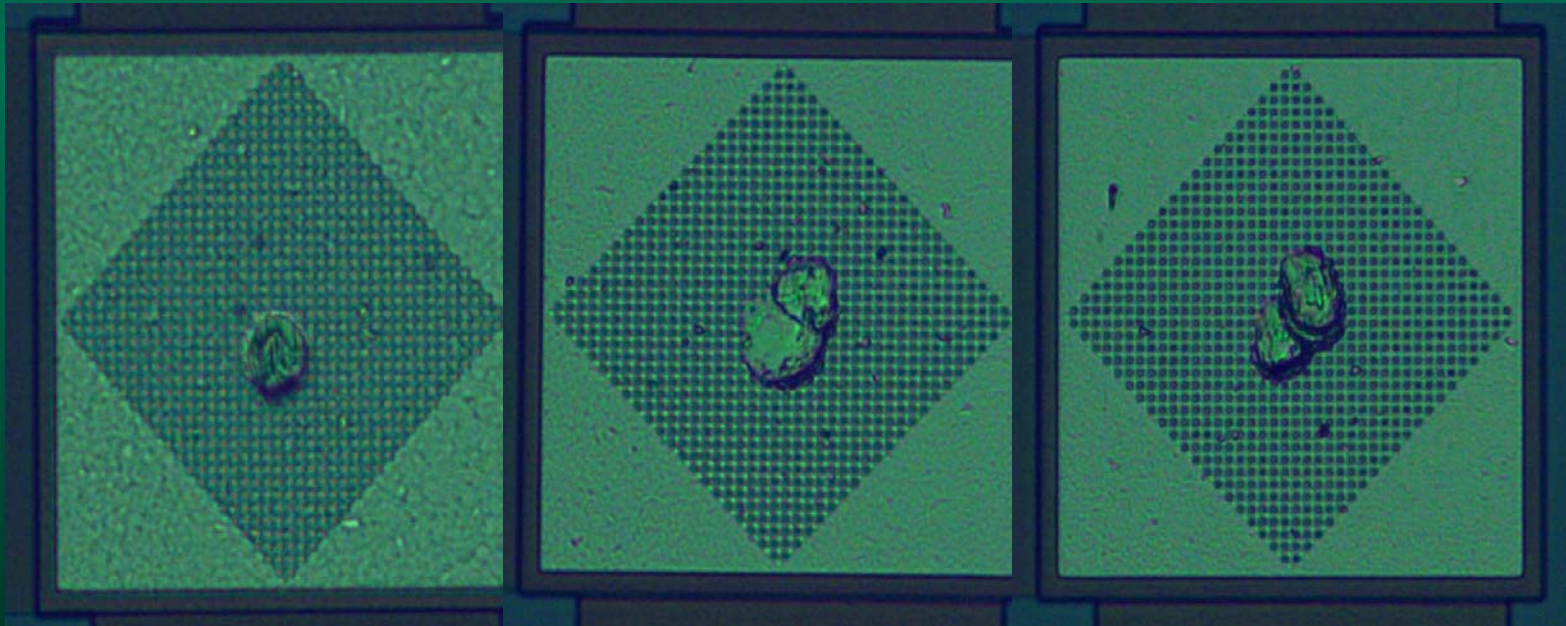
ViProbe[®] Probe Marks post 3 pass Sort.



3 Cantilever Probe Scrubs breaking Pad Edge



ViProbe[®] on Al Pad.



Pass 1

Pass 2

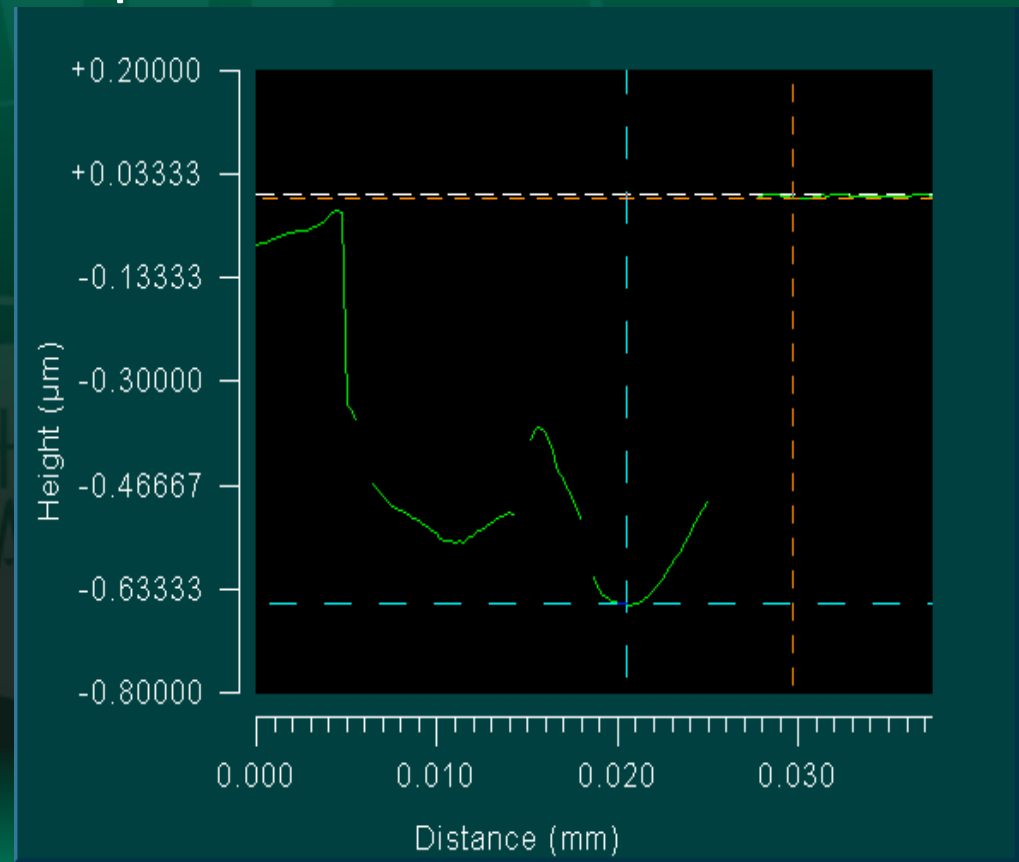
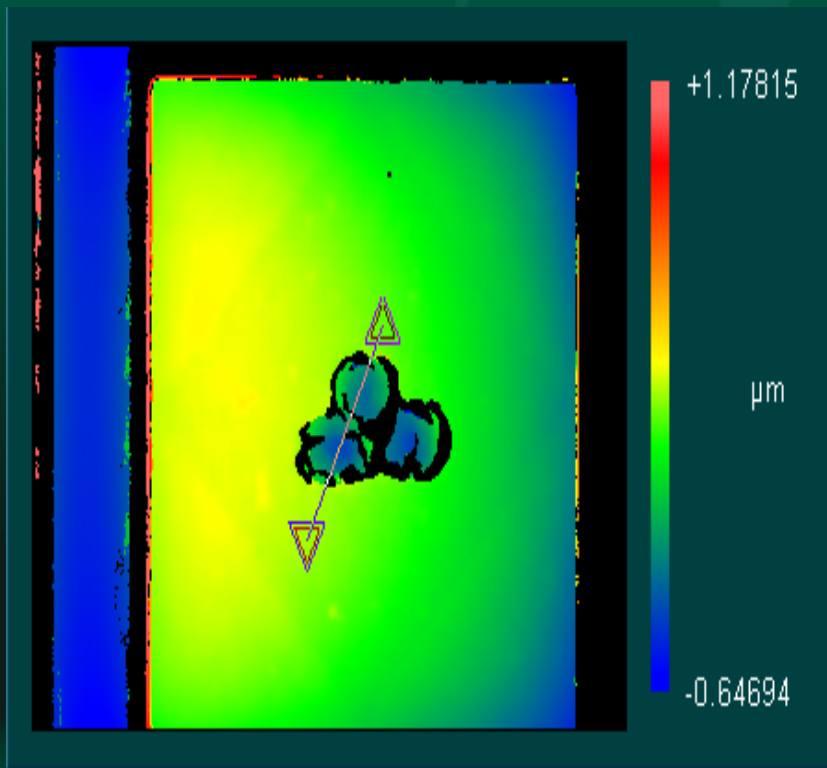
Pass 3

- **NSX 105 post Pass 3**
 - Probe Mark Area = $546\mu\text{M}^2$,
 - Probe Mark % of Pad = 3.8%
 - Pad Edge Proximity = $35\mu\text{M}$.



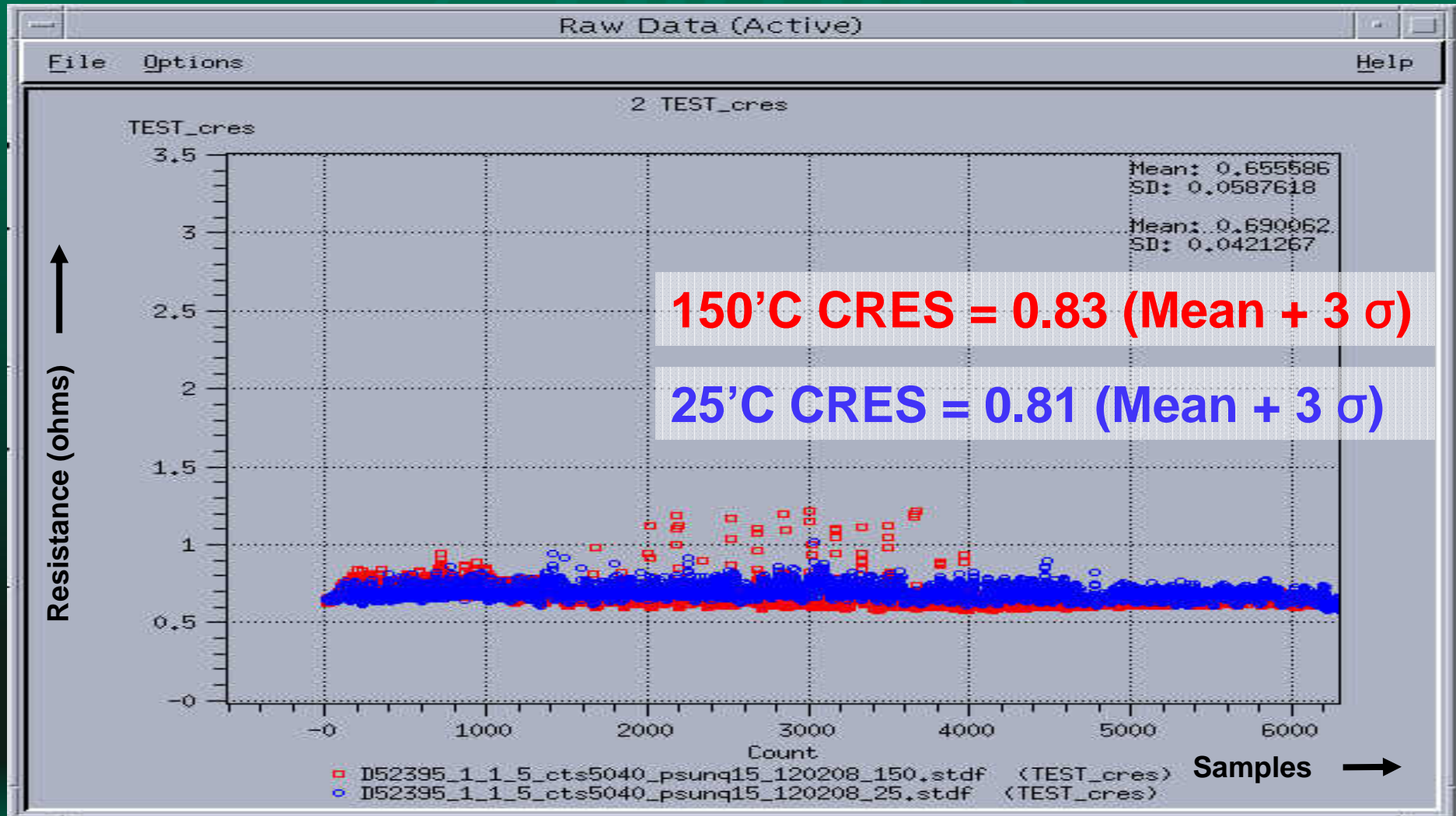
ViProbe[®] on Al Pad.

- Zygo Profilometer.
- Depth of ViProbe[®] Scrub on Al Pad post Pass 3,
 - Probe Mark Depth = $0.6\mu\text{M}$



ViProbe[®] on Al Pad.

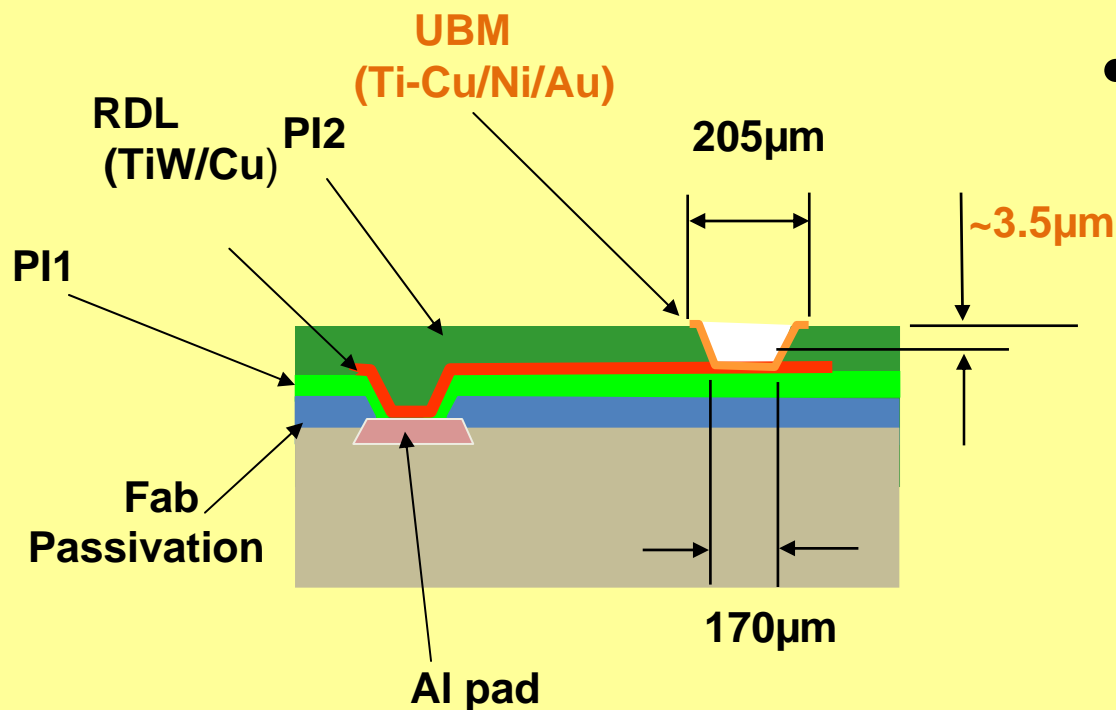
- CRES baseline 0.6 Ohm, CRES stable over temperature



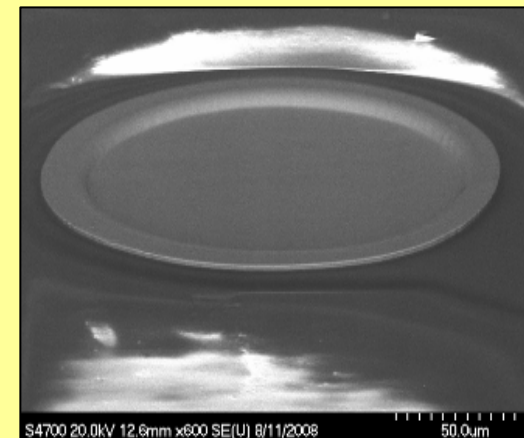
ViProbe[®] on Au Pad.

- EWLP – Embedded Wafer Level Package.

- WLCSP (Minus Bump)

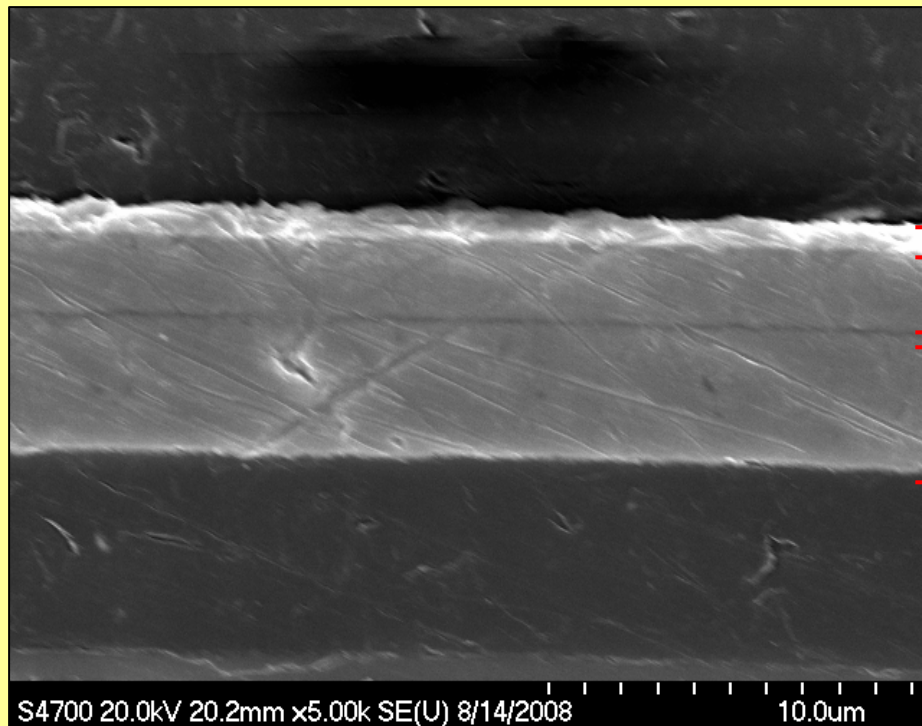


- SEM of UBM Pad



ViProbe[®] on Au Pad.

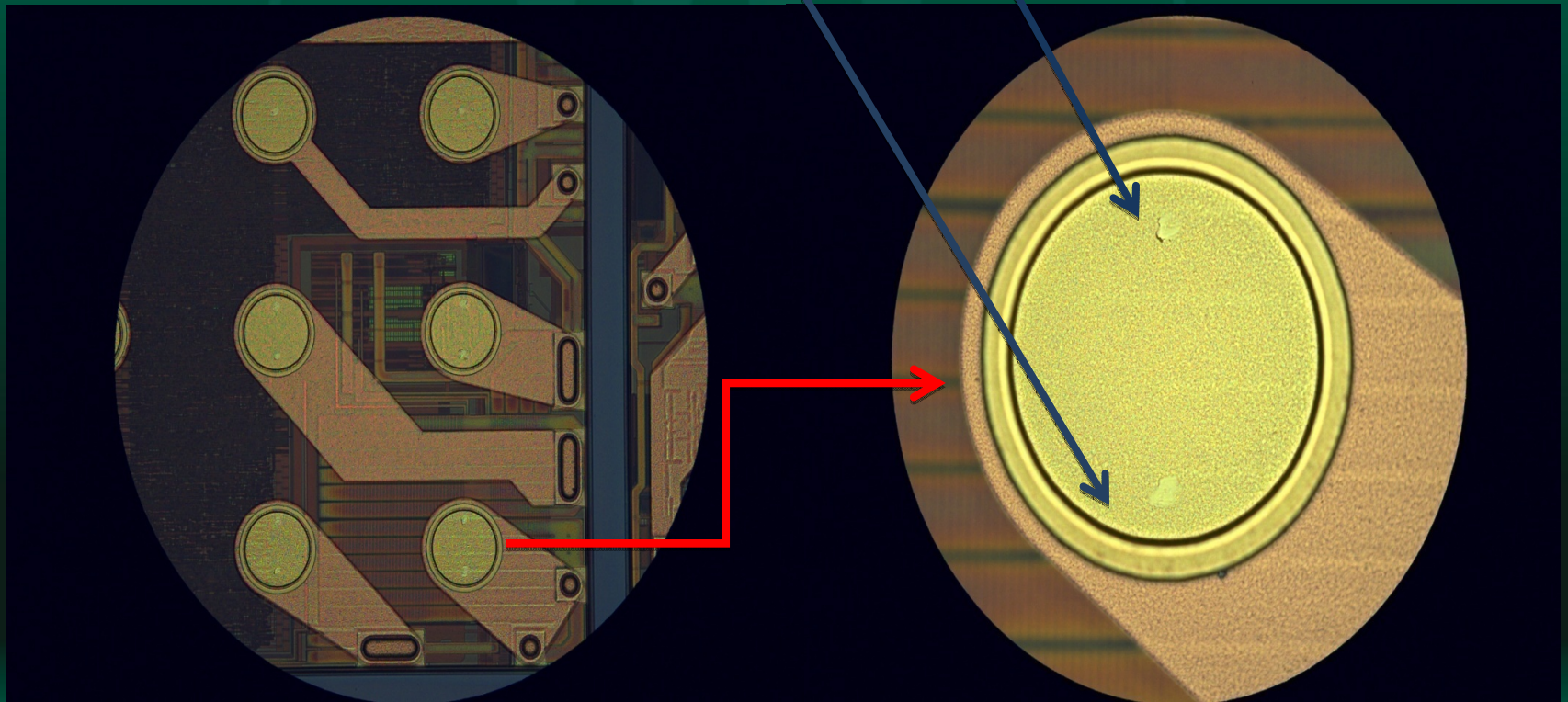
- EWLP – Au Pad of $\sim 1\mu\text{M}$ Au Flash,
- Post Sort Requirement: No Punch Thru.



* ← $\sim 1\mu\text{m}$ layer of Gold
← Nickel
← Titanium
← Copper

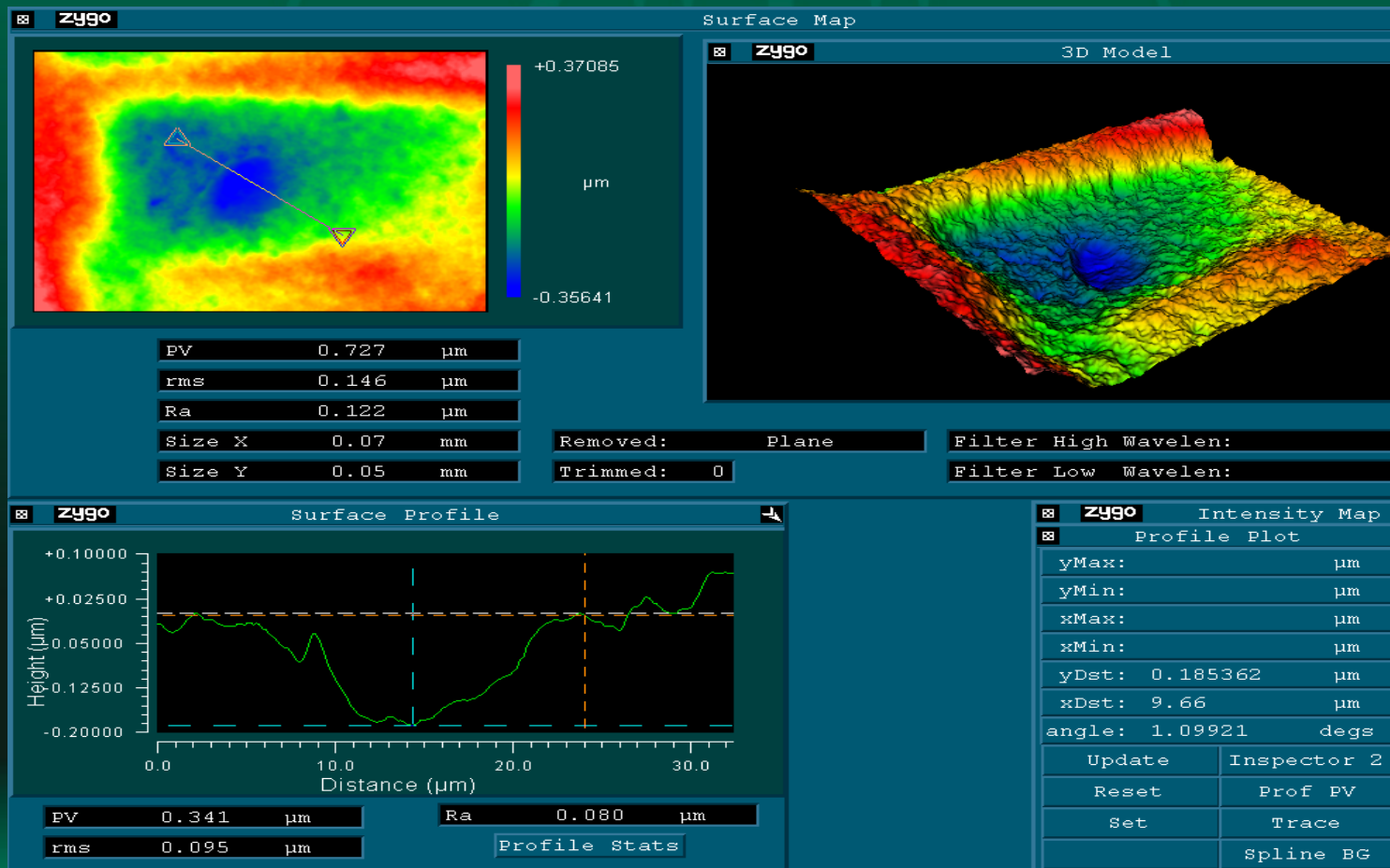
ViProbe[®] on Au Pad.

- 2D PMI (Leica microscope),
- Scrub Mark area $\sim 400\mu\text{M}^2$.
 - ViProbe[®] Kelvin at $86\mu\text{M}$ pitch.



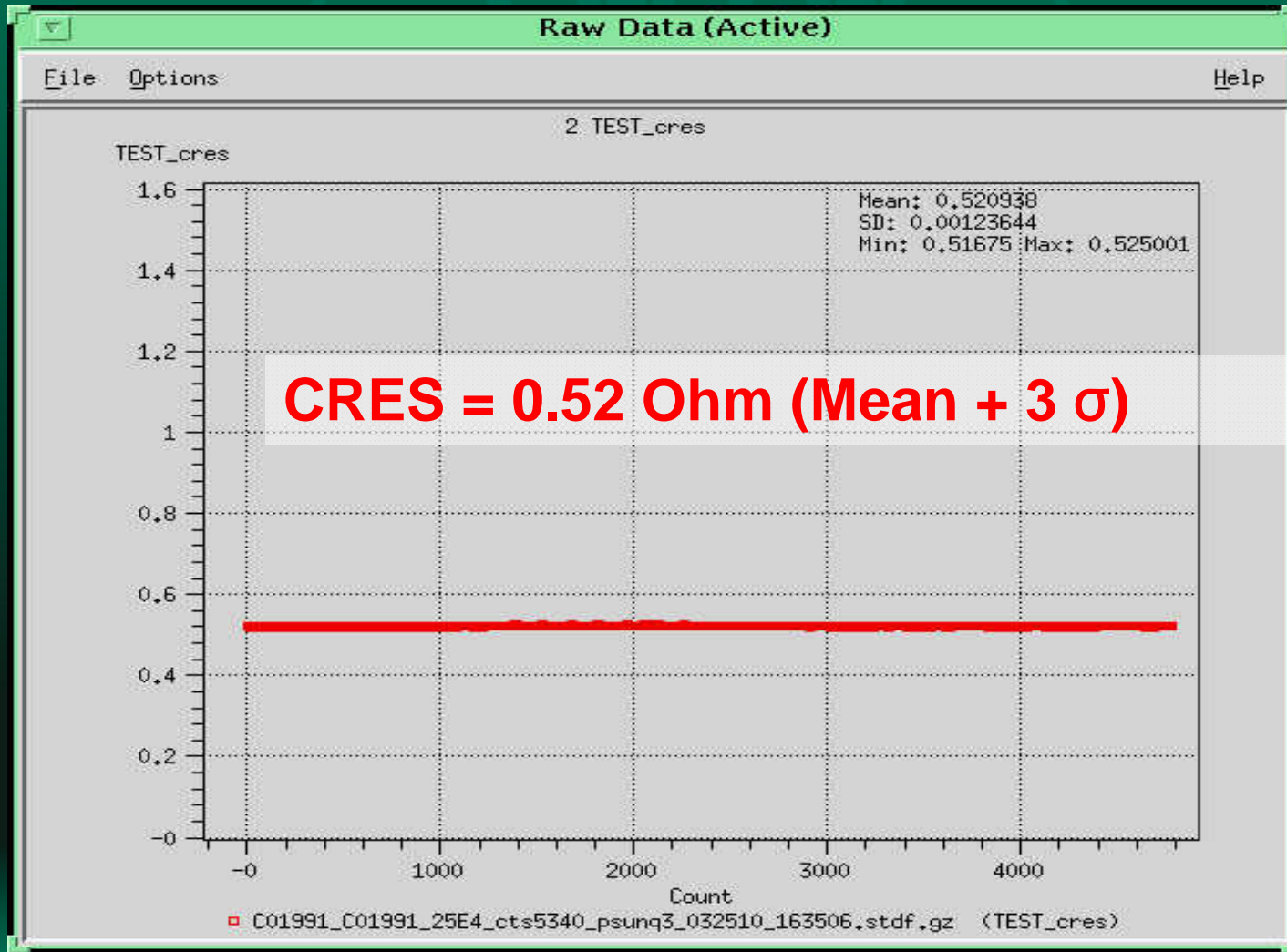
ViProbe[®] on Au Pad.

- 3D PMI (Zygo Profilometer).
- Depth of ViProbe[®] Scrub on Au Pad = 0.185 μ M



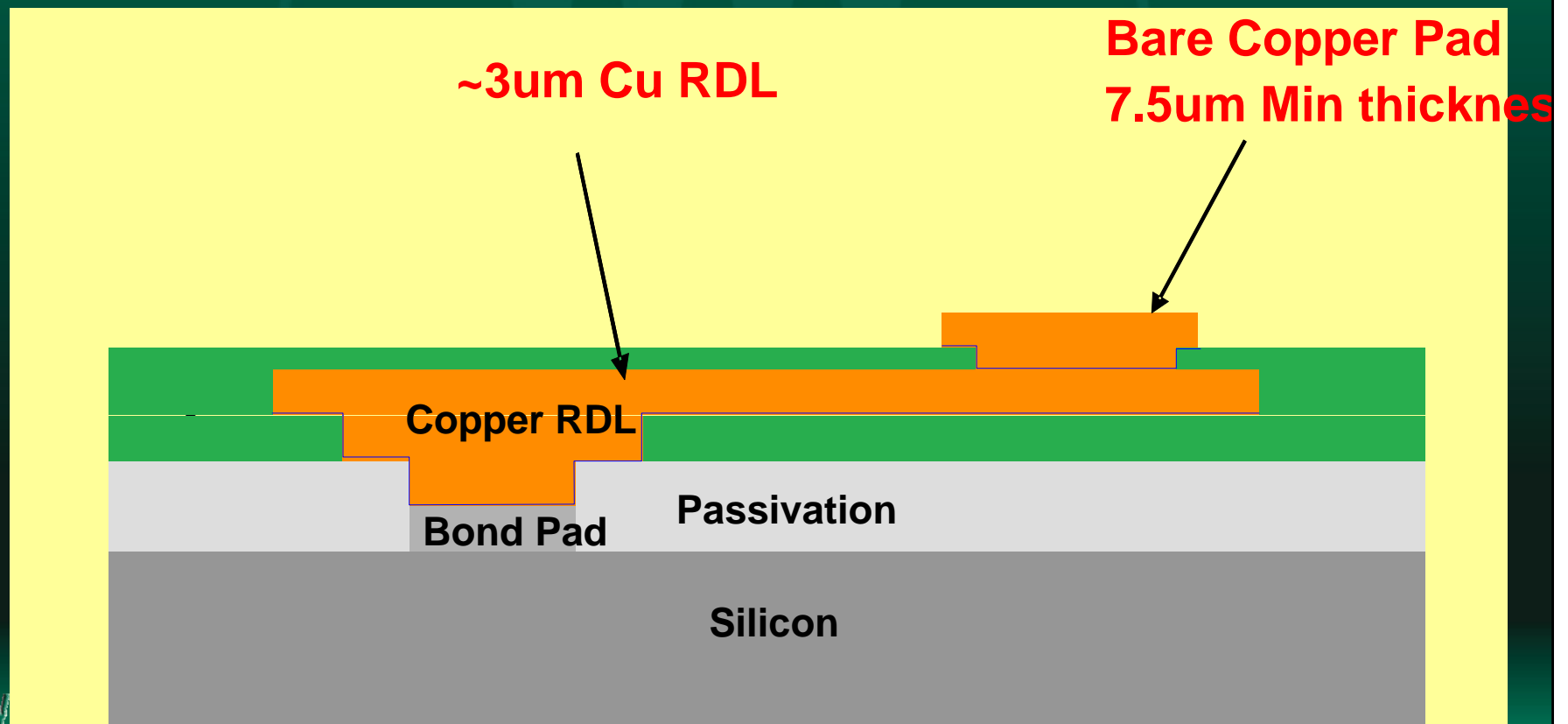
ViProbe[®] on Au Pad.

- CRES at 125'C, No Online Clean required.



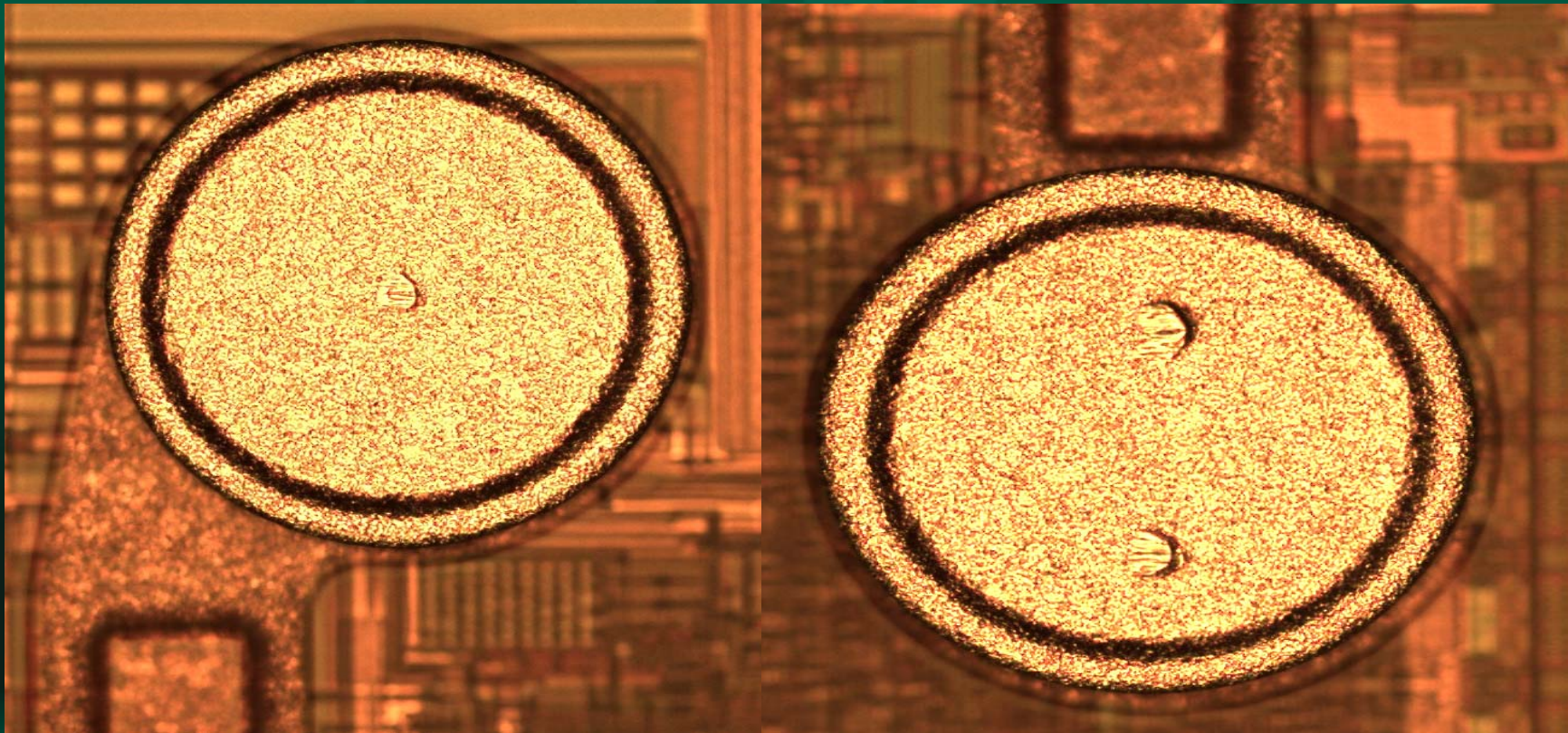
ViProbe[®] on Cu Pad.

- Cu RDL + Cu Pad.
- Concern was oxidation and the resulting difficulty of making good electrical contact.



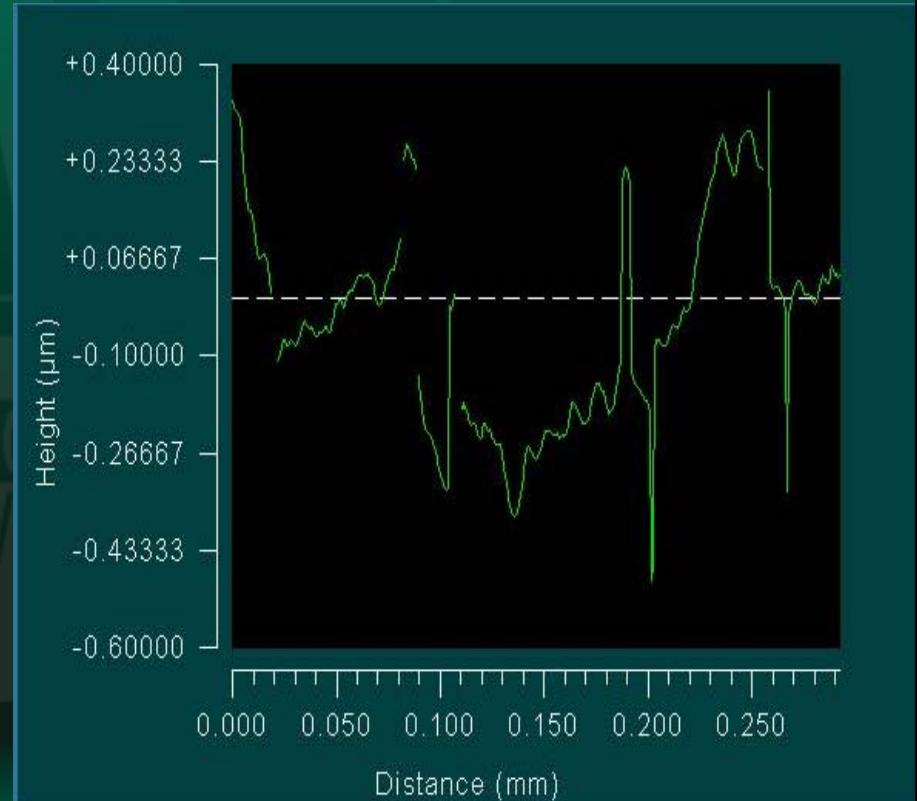
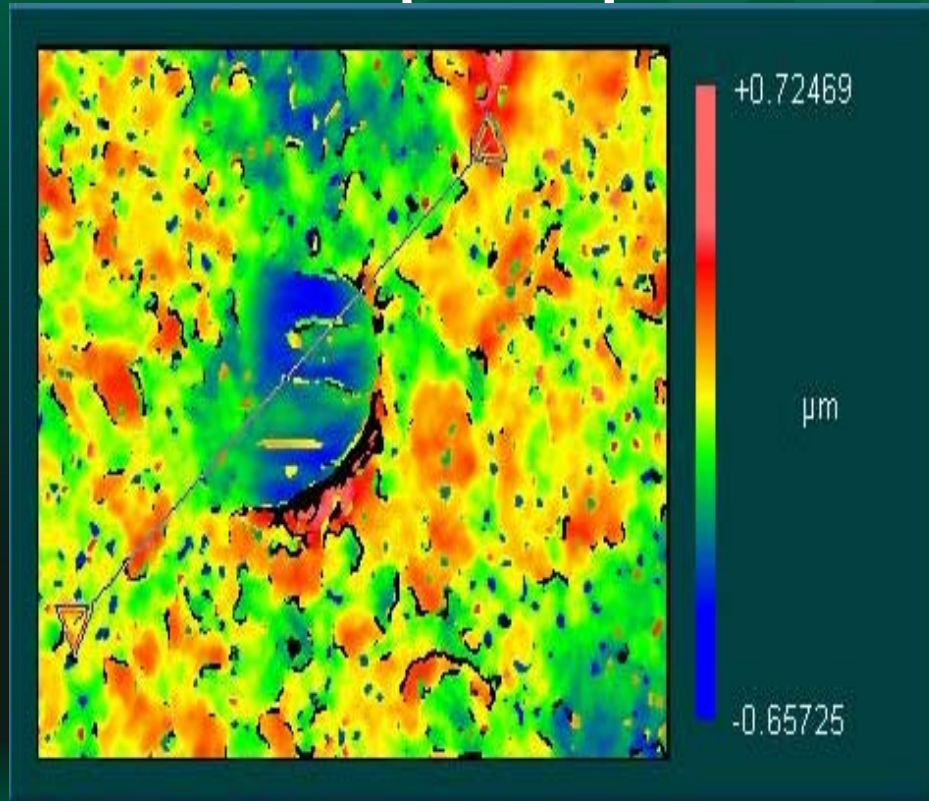
ViProbe[®] on Cu Pad.

- 2D PMI (Leica microscope).
 - Single and Kelvin Probe Marks.



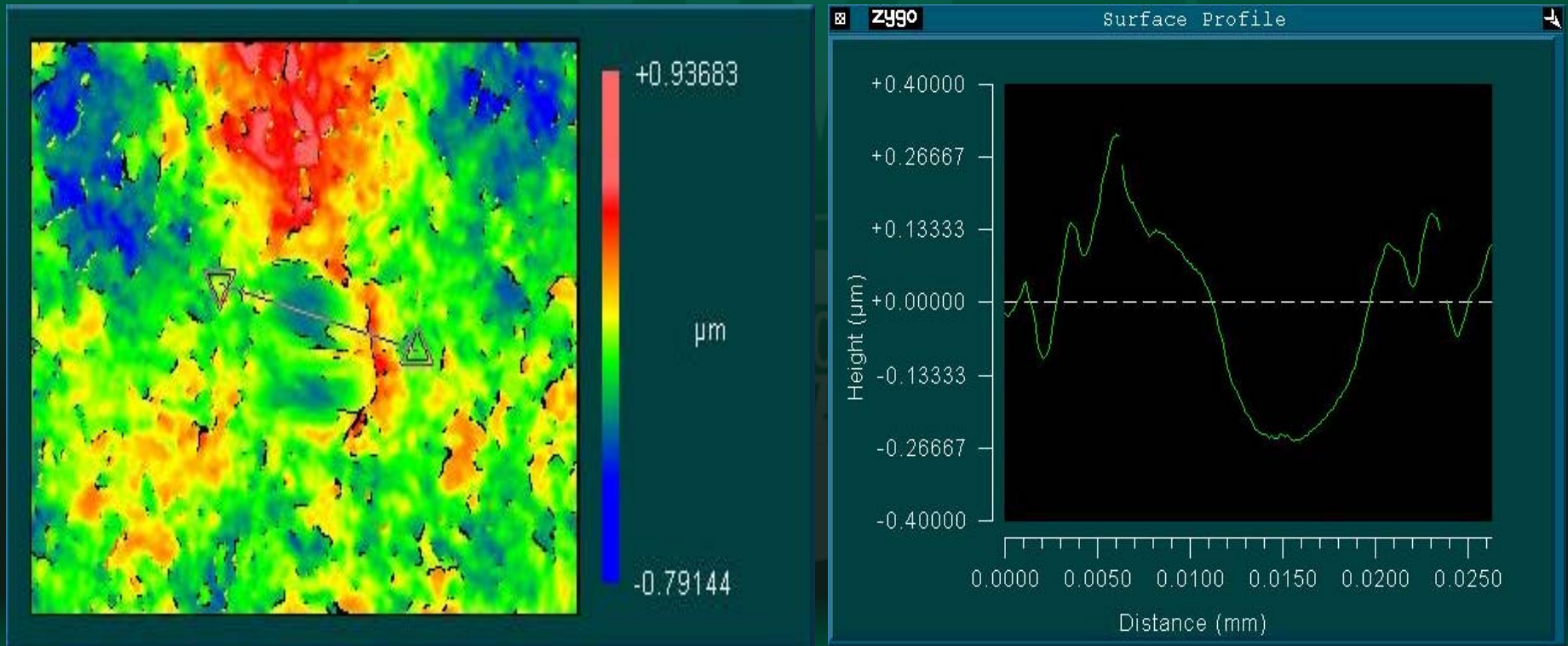
ViProbe[®] on Cu Pad.

- 3D PMI (Zygo Profilometer).
 - Noisy result for a single touchdown,
 - $\sim 0.360\mu\text{M}$ depth.



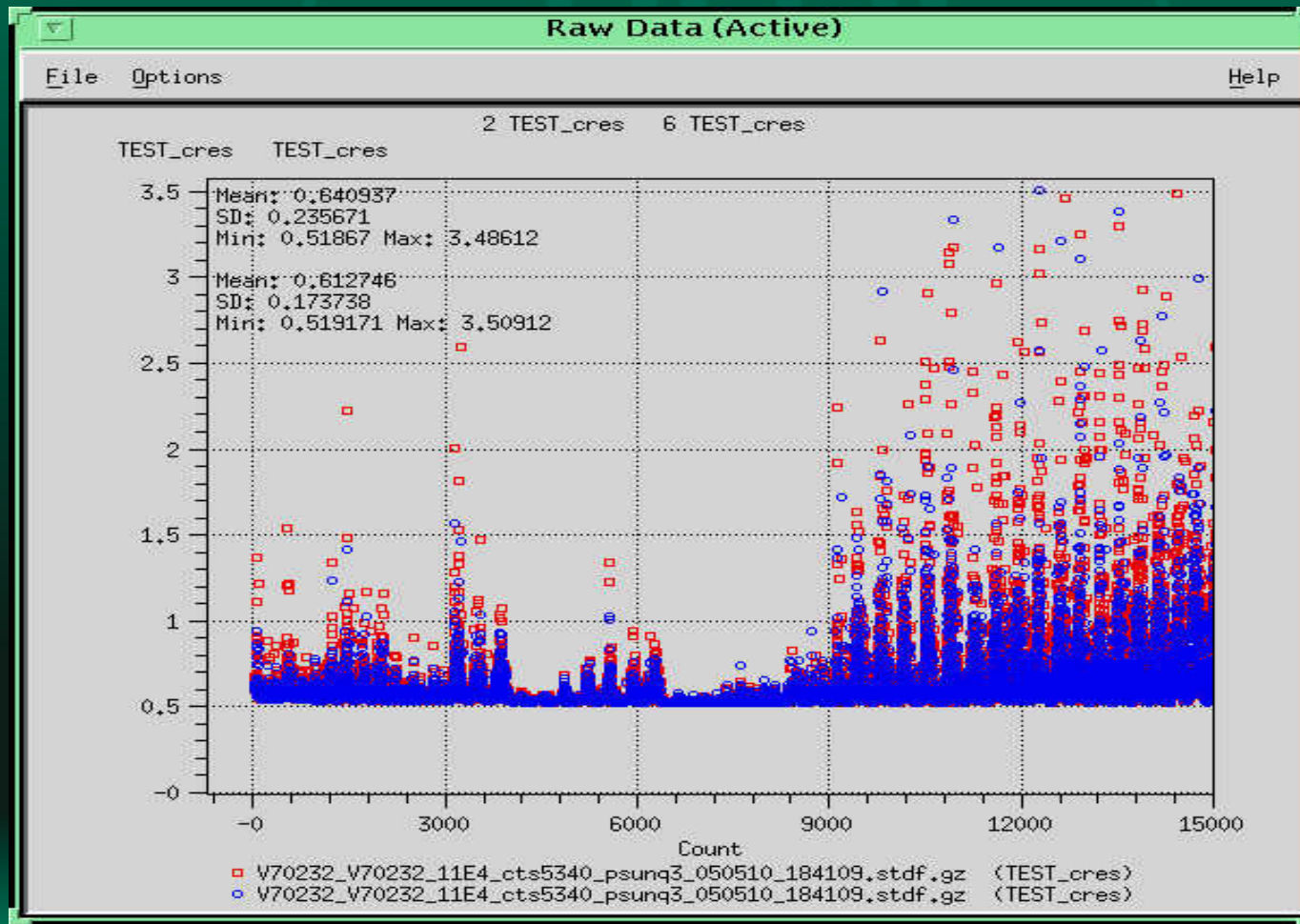
ViProbe[®] on Cu Pad.

- 3D PMI (Zygo Profilometer).
 - x10 touchdown (flattening effect from re-probe),
 - 0.266 μ M depth.



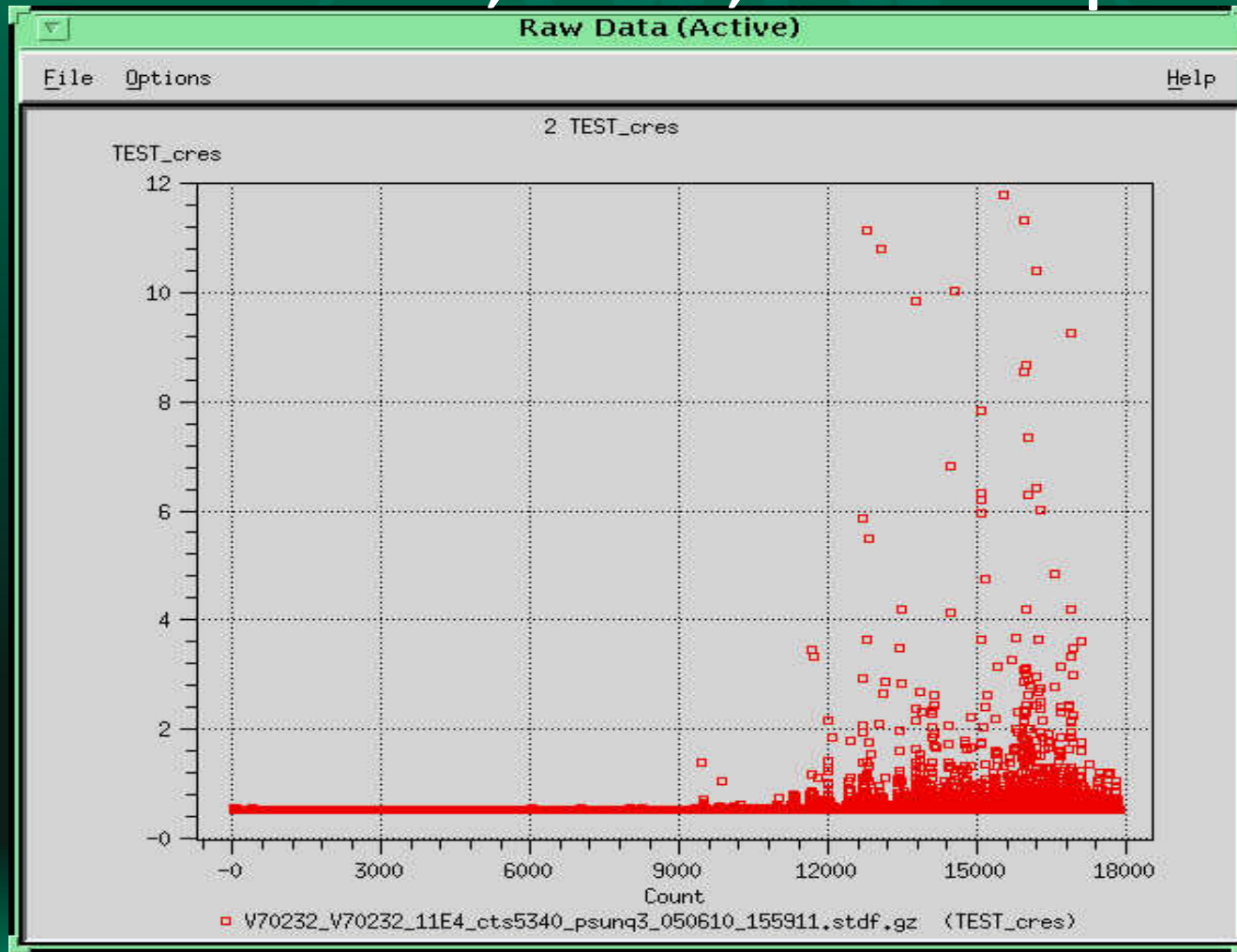
ViProbe[®] on Cu Pad.

- Measure CRES, Force 30mA, Measure CRES.
 - Fritting has a slight improvement on unstable CRES.



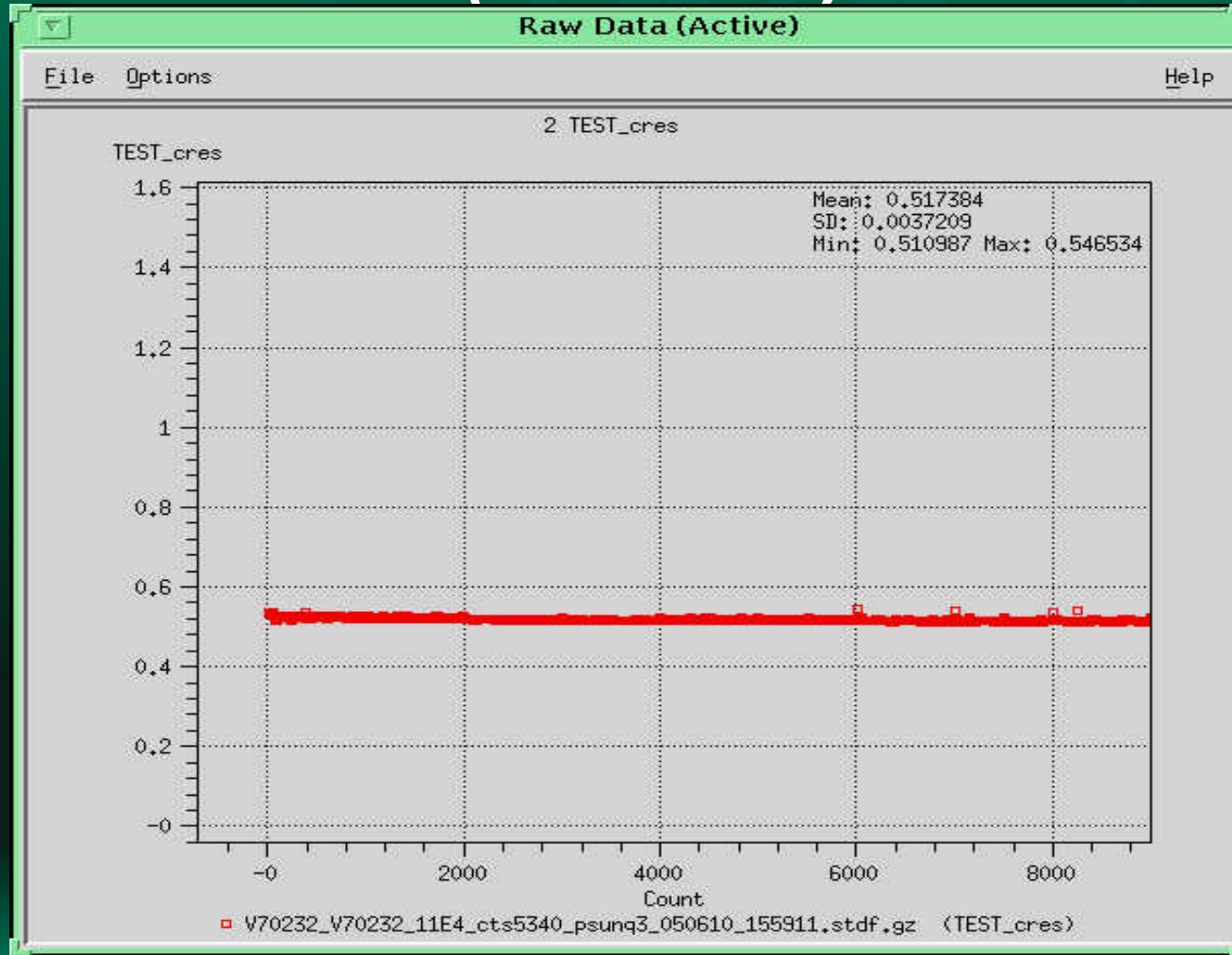
ViProbe[®] on Cu Pad.

- Online Clean (ITS Probe Polish, every 1K Tds).
 - Stable CRES to 9,000 Tds, Need to improve?



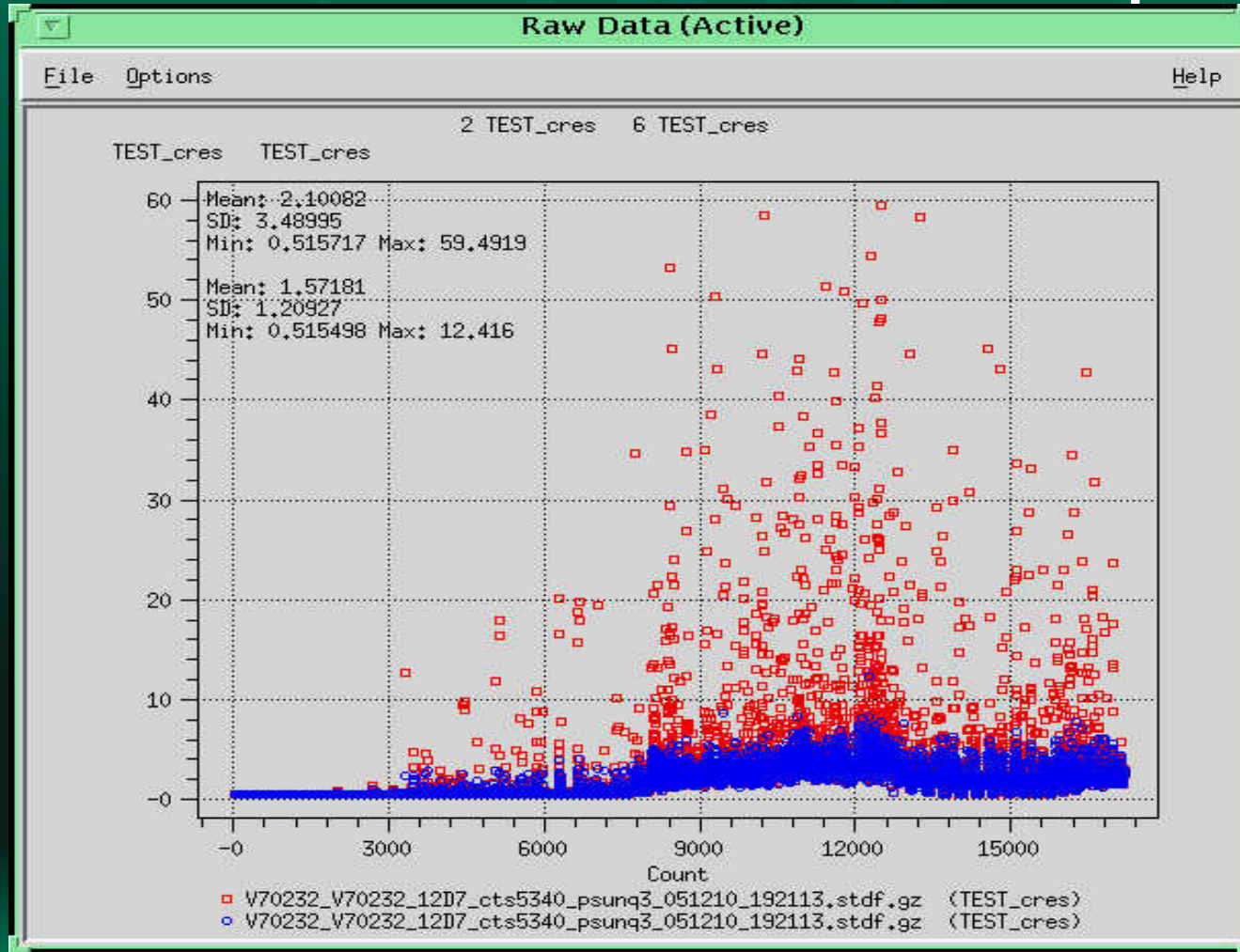
ViProbe[®] on Cu Pad.

- Online Clean (ITS Probe Polish, every 1K Tds).
 - Cu CRES = 0.53 (Mean + 3 σ) to 9K Tds.



ViProbe[®] on Cu Pad.

- Cu at 125°C (setup verification at Ambient to 1K Tds).
 - Cu CRES unstable from ~3K Tds at temperature.



ViProbe[®] on Cu Pad.

- **Cu CRES Summary:**

- At ambient temperature, CRES stable to 9K Tds,
 - But online Clean needed.
- Many hours on Sort floor trying to extend CRES stability above 9K Tds,
 - No definite solution
 - ViProbe[®] Technology good, Cu Challenging.
- Long Term solution is to work with ITS and Feinmetall to find optimum online Clean recipe.



Motivation.

ViProbe[®] Vertical Probe Technology.

CRES Measurement setup.

Evaluation Results Al, Au, Cu Pad.

ViProbe[®] Temperature Probe @ 200'C.

ViProbe[®] ADC Testing in Probe to Data
Sheet specifications.

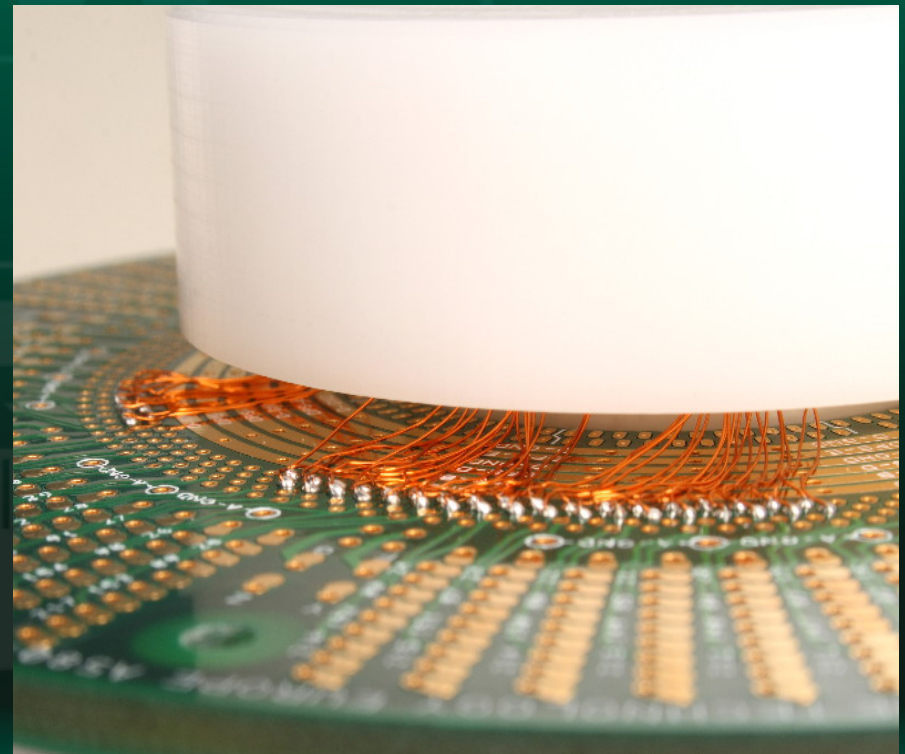
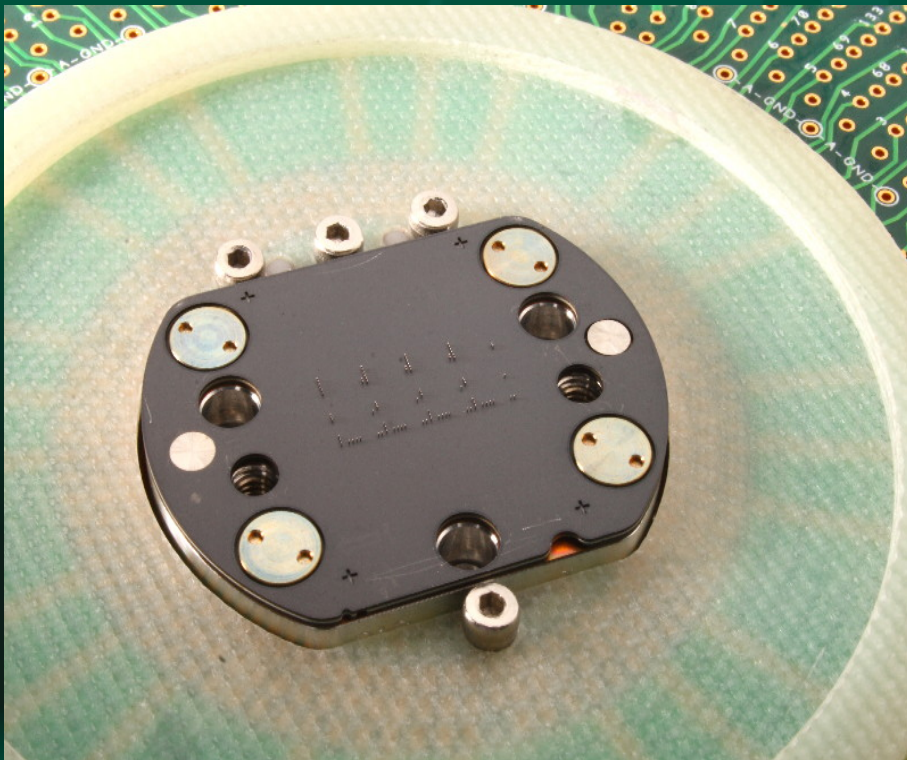
Conclusions.

Future Work.



ViProbe[®] Temperature Probe 160'C.

- 3 Pass Automotive Probe Card.
- Feinmetall specification 150'C, used at 160'C.
- ADI requirement for >160'C capability.



ViProbe[®] Temperature Probe 200°C.

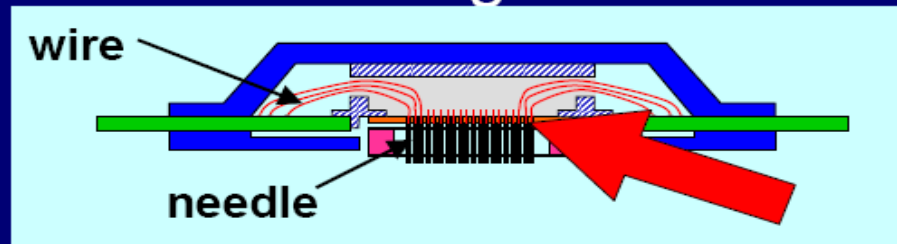
- Use existing automotive solution as test vehicle for measuring Max temperature capability.
- Evaluation involved testing product with +5°C increments in temperature.
- Existing solution worked to 170°C, at 175°C open circuit failures,
 - But Probe Marks still centre of Pad?



ViProbe[®] Temperature Probe 200'C.

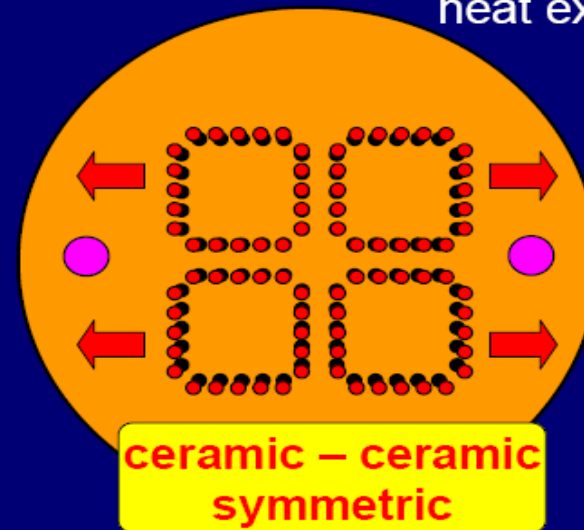
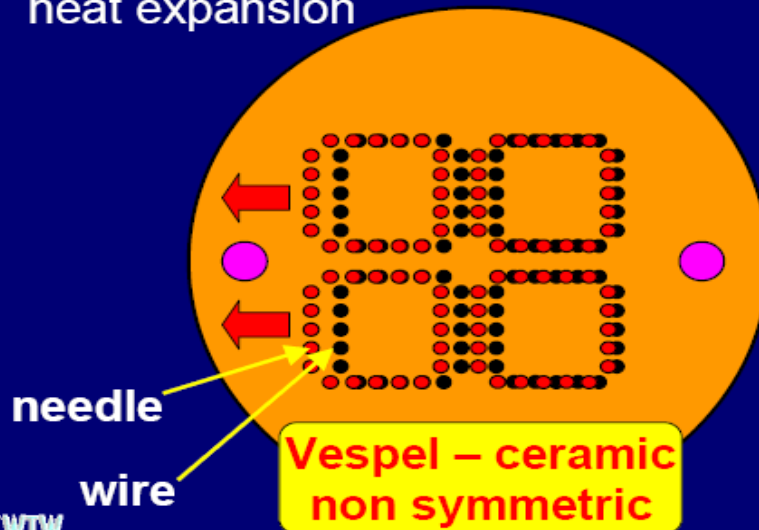
- SchaeferBoehm et al SWTW paper 2009.
- Probe Head to Connector contact point issue.

3. Needle – Connector Alignment



old style
heat expansion

new design
heat expansion



June 2009

FEINMETALL GmbH, Dr. W. Schaefer / G. Boehm

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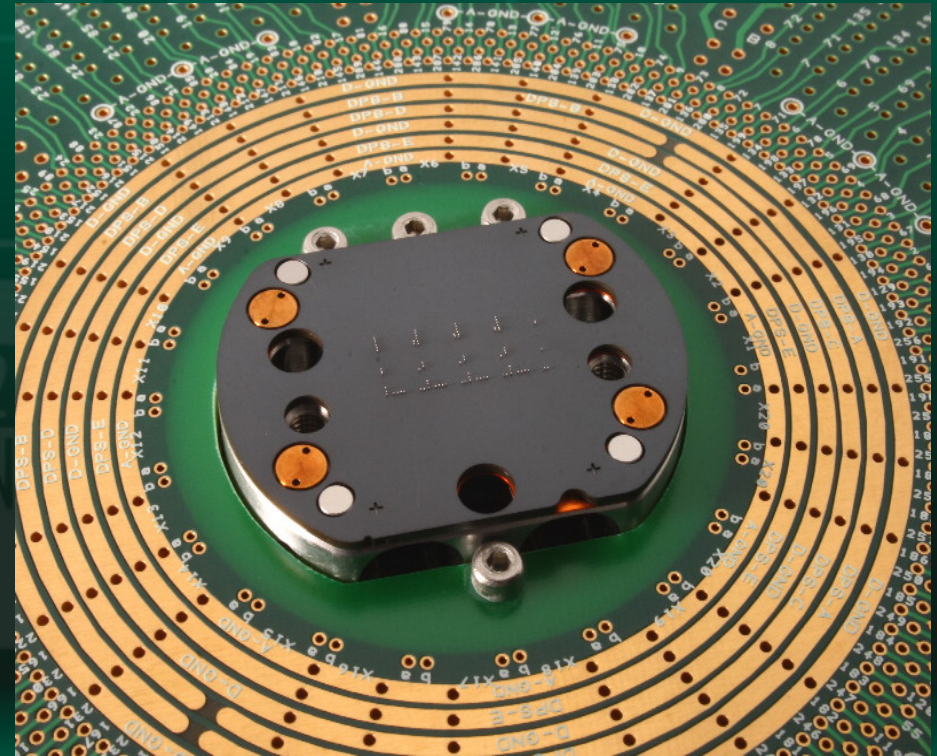
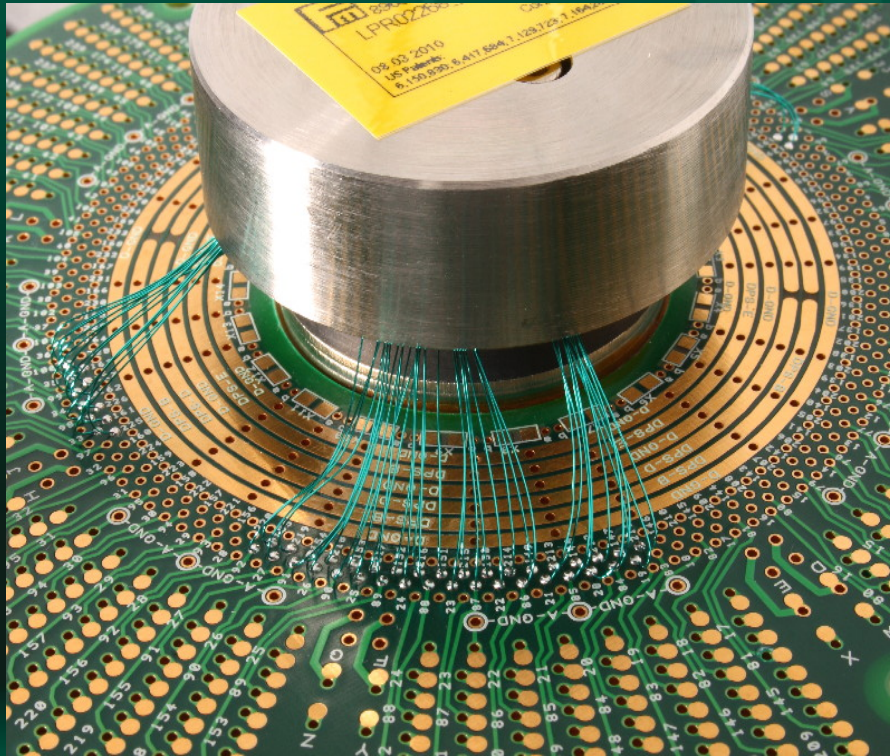
June 6 to 9, 2010

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ViProbe[®] Temperature Probe 200'C.

- 200'C W41 ViProbe[®] Probe Card (No O/C Fails).
 - Using higher temperature specification materials.
 - >200'C possible with 'Heat Shield' and higher T_g PCB.



June 6 to 9, 2010

IEEE SW Test Workshop

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Motivation.

ViProbe[®] Vertical Probe Technology.

CRES Measurement setup.

Evaluation Results Al, Au, Cu Pad.

ViProbe[®] Temperature Probe @ 200'C.

ViProbe[®] ADC Testing in Probe to Data Sheet specifications.

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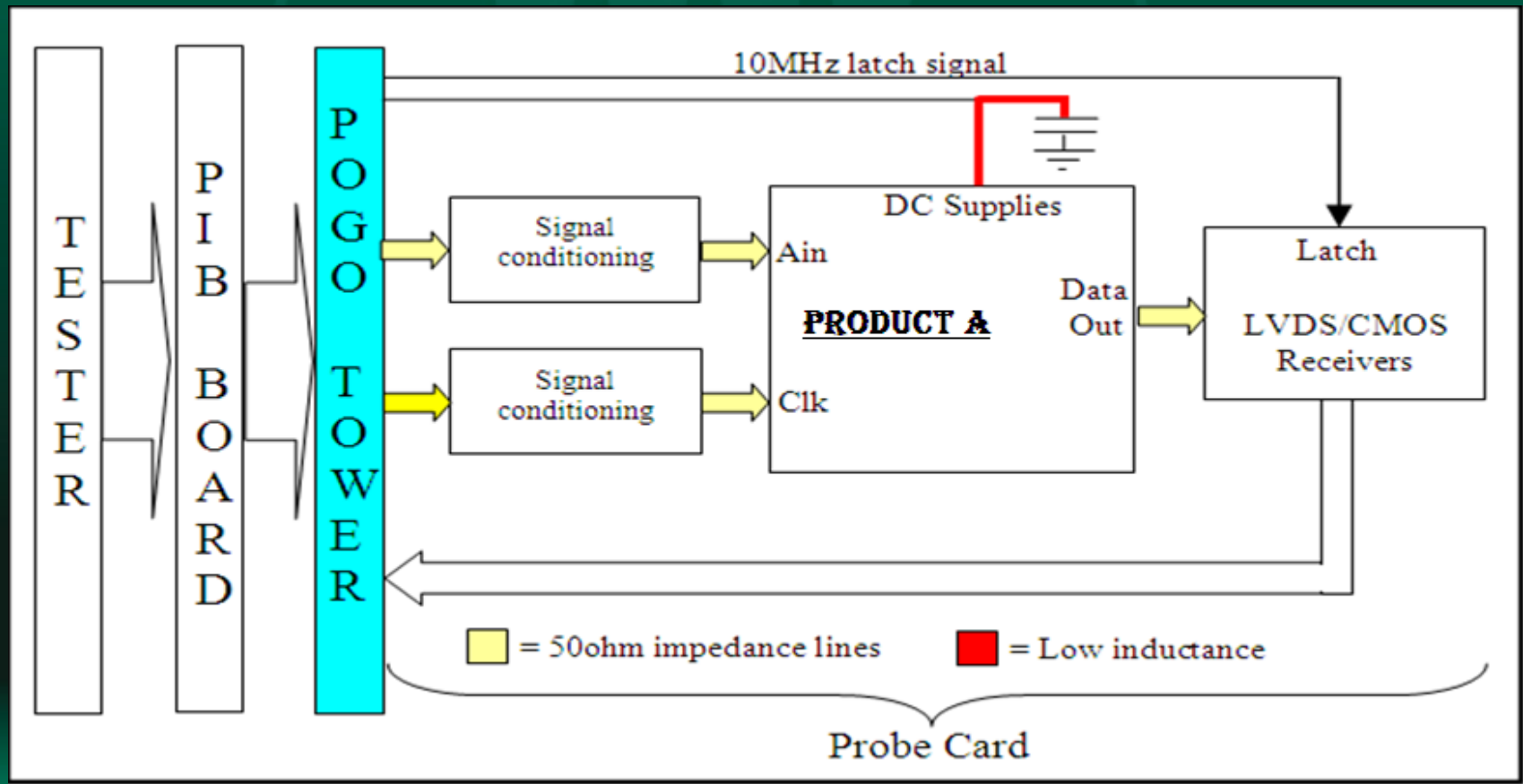
ViProbe[®] ADC Testing in Probe to Data Sheet Specifications.

- Objective: Can KGD be provided at Probe for a 210MSPS ADC (Product A) and similar high speed converters.
- Use Product A performance results (INL/DNL, and SNR) as an indication of the influences of the 'Probe Card' on the signal paths and decoupling.
 - Existing KGD High Performance Cantilever solutions already available.
 - Need a Vertical Technology KGD capability.



ViProbe[®] ADC Testing in Probe to Data Sheet Specifications.

- Low Inductance decoupling.
- 50 Ohm impedance as close to DUT as possible.



ViProbe[®] ADC Testing in Probe to Data Sheet Specifications.

- **ViProbe[®] Solution.**
 - Direct Attach ViProbe[®] Probe Card with custom PCB (all signal conditioning components on PCB).
 - PCB layout based on working Cantilever solutions.
 - ADI supplied PCB, Direct Attach ViProbe[®] Head from Feinmetall.
- **Results:** Are for INL/DNL, SNR (10.3 & 70MHz) for
 - Data sheet spec,
 - A Final test part tested on the same tester,
 - ViProbe[®] Direct Attach solution.



ViProbe[®] ADC Testing in Probe to Data Sheet Specifications.

- INL Results.
- Final test program limit:
 - INLn: -1.5lsb to 0.0lsb
 - INLp: 0.0lsb to 1.5lsb
 - No missing codes

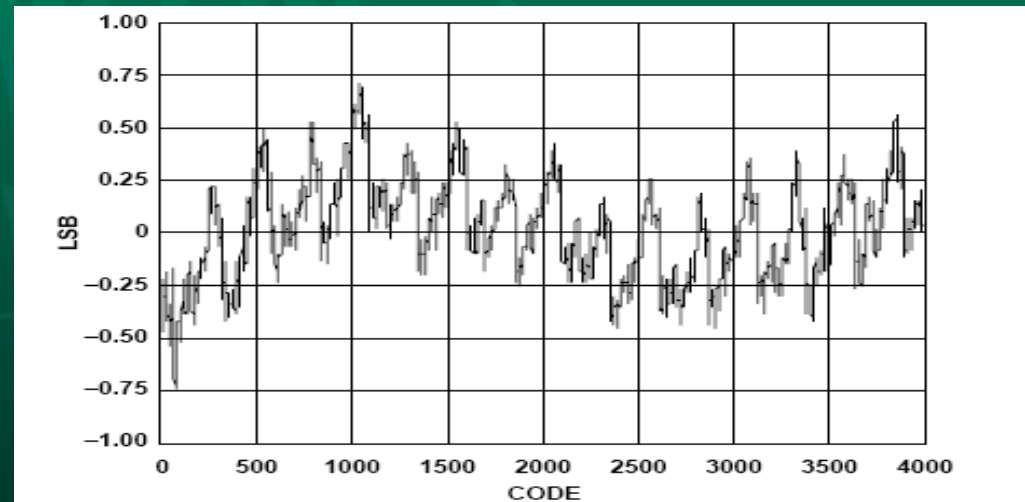
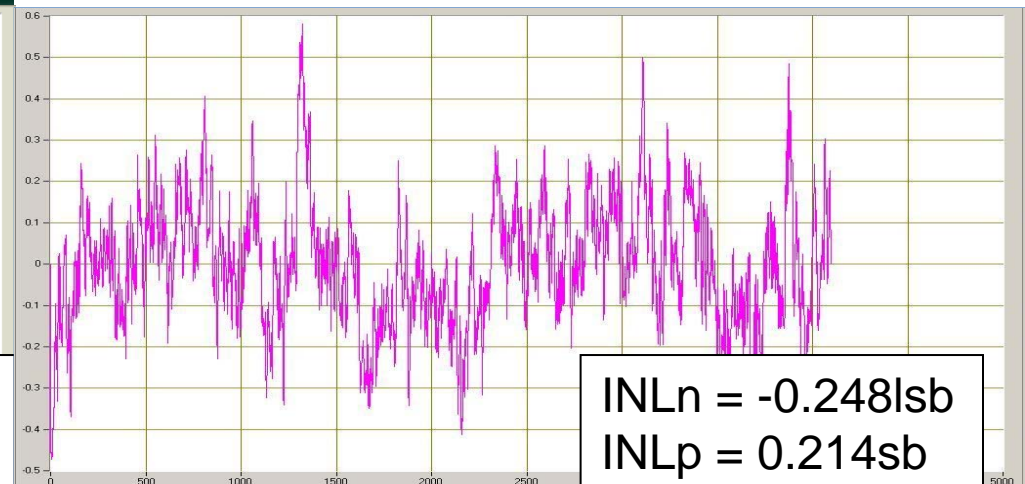
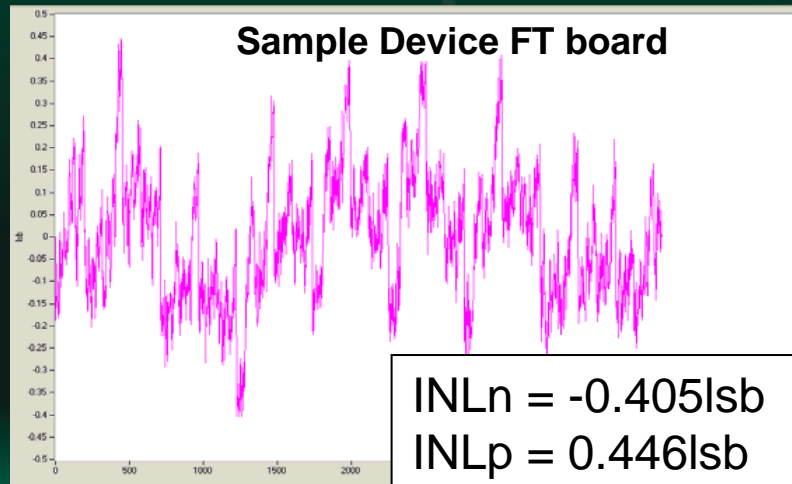


Figure 39. Typical INL Plot ($A_{IN} = 10.3 \text{ MHz @ } -0.5 \text{ dBFS, } 170 \text{ MSPS, LVDS}$)



ViProbe[®] ADC Testing in Probe to Data Sheet Specifications.

- DNL Results.
- Final test program limit:
 - DNL_n: -0.850lsb to 0.0lsb
 - DNL_p: 0.0lsb to 0.850lsb

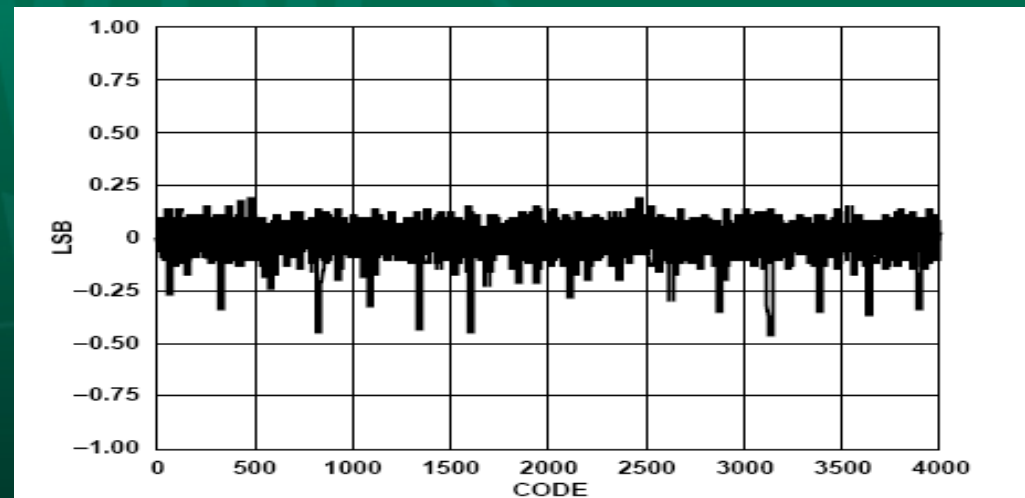
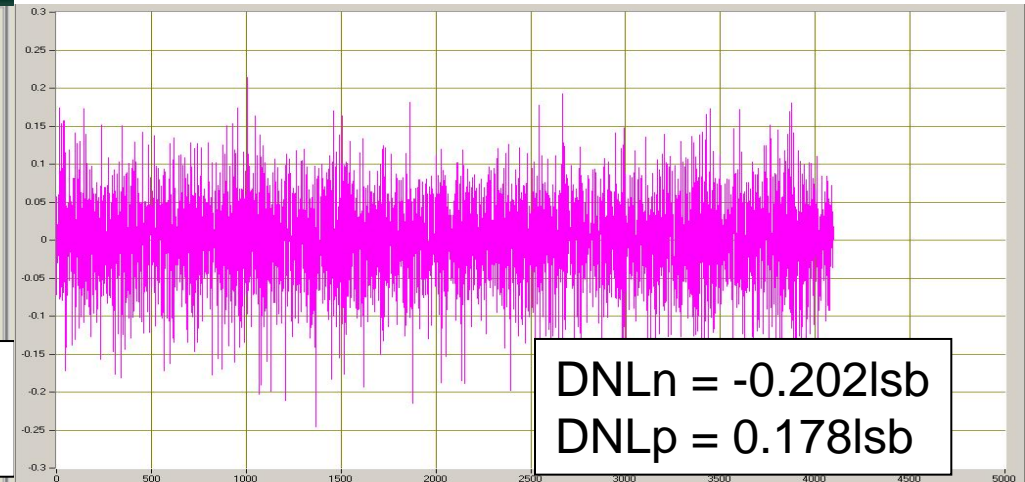
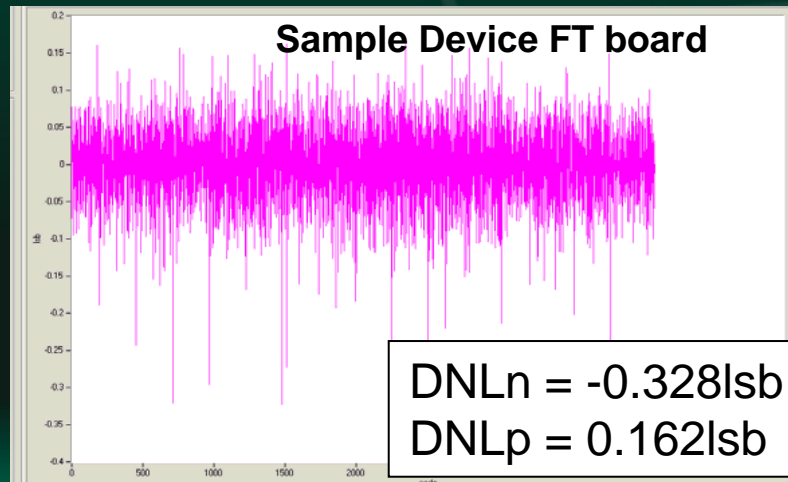


Figure 40. Typical DNL Plot ($A_{IN} = 10.3 \text{ MHz @ } -0.5 \text{ dBFS}$)



ViProbe[®] ADC Testing in Probe to Data Sheet Specifications.

- SNR / SINAD Results.
- Final test limit (Fin = 10.3 MHz):
 - SNR: 62.9dB
 - SINAD: 62.9dB
 - H2: -75dB
 - H3: -75dB

Sample Device FT board

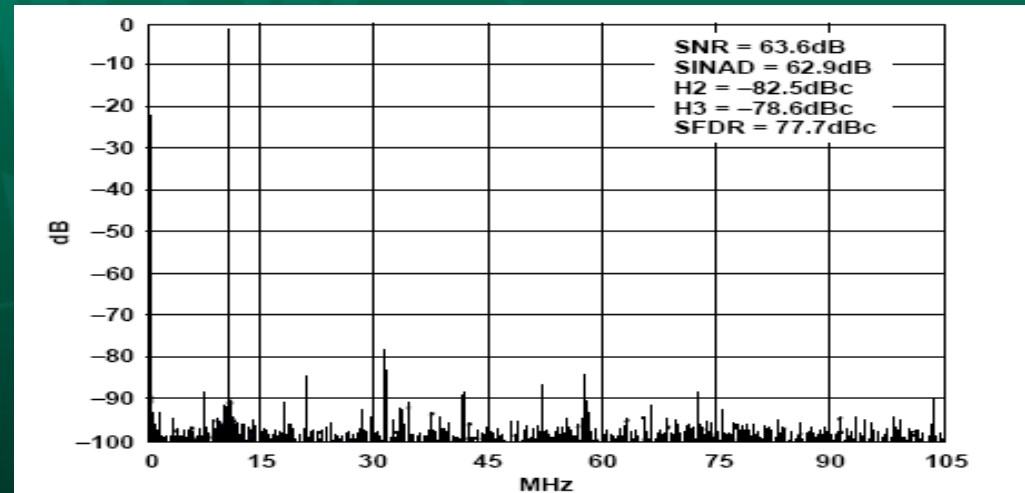
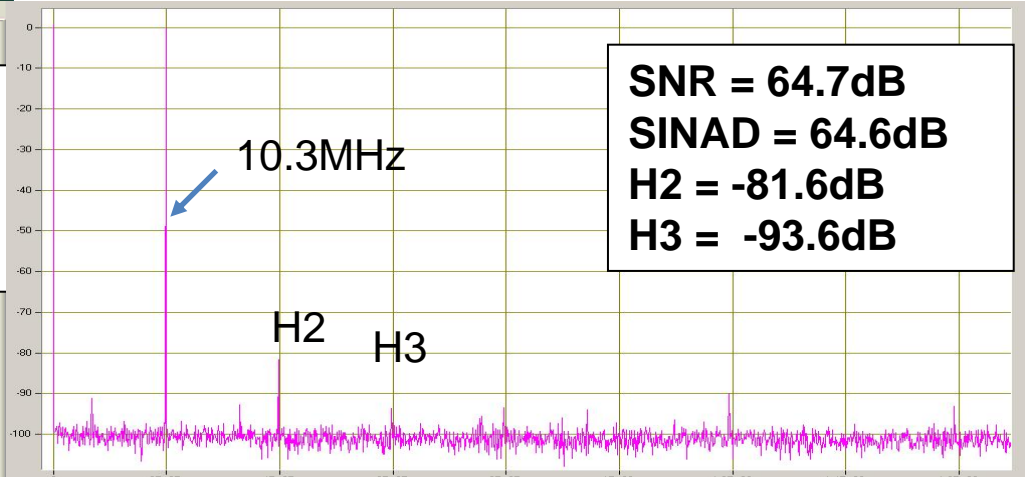
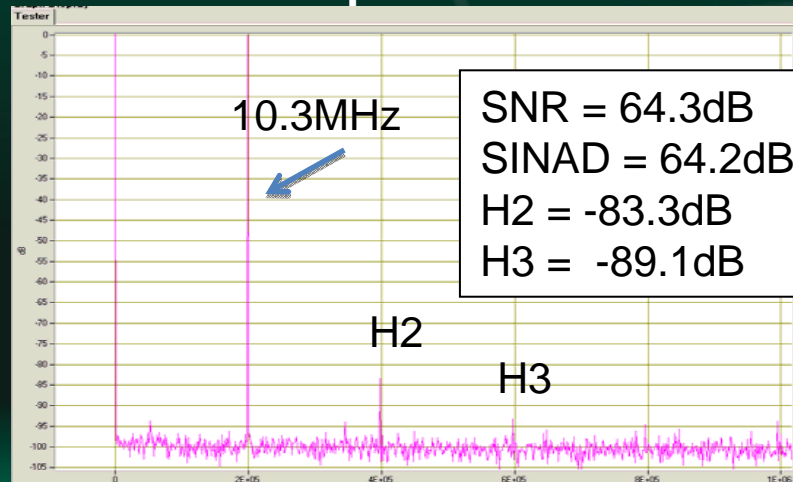


Figure 16. FFT: $f_s = 210$ MSPS, $A_{IN} = 10.3$ MHz @ -0.5 dBFS, LVDS Mode



ViProbe[®] ADC Testing in Probe to Data Sheet Specifications.

- SNR / SINAD Results.
- Final test limit (Fin = 70 MHz):
 - SNR: 62.9dB
 - SINAD: 62.9dB
 - H2: -75dB
 - H3: -75dB

Sample Device FT board

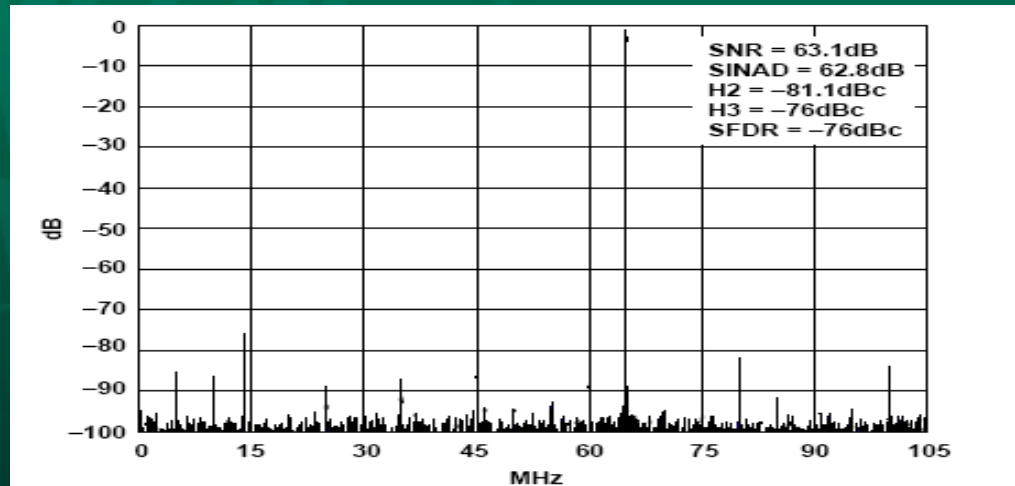
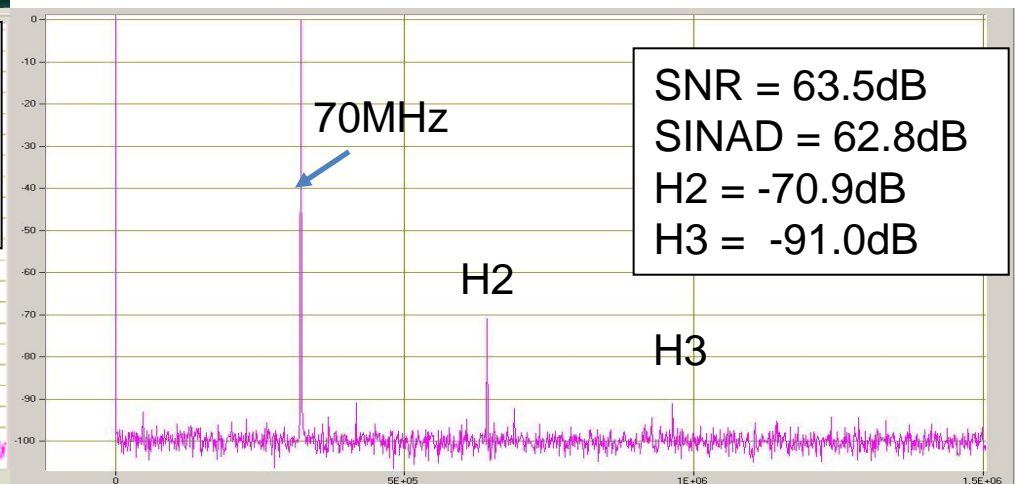
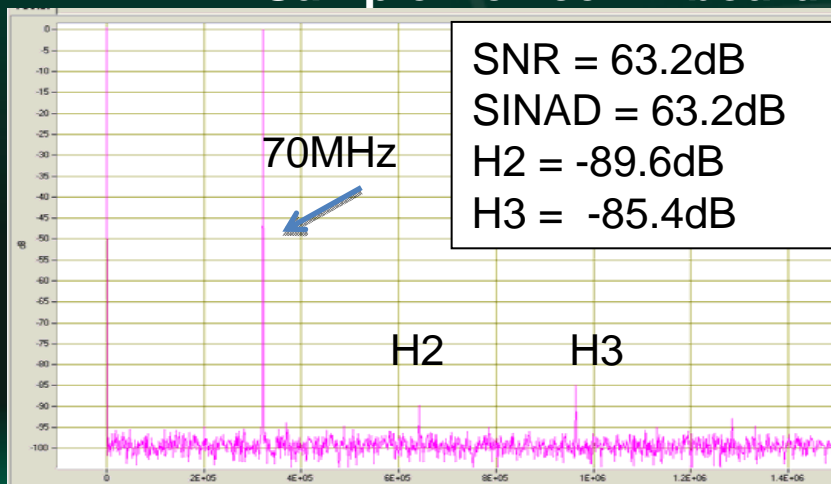


Figure 17. FFT: $f_s = 210$ MSPS, $A_{IN} = 65$ MHz @ -0.5 dBFS, CMOS Mode



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Conclusions.

- **ViProbe[®] used successfully to Sort multiple Pad Compositions Al, Au, and Cu.**
- **Presented Post ViProbe[®] data for Al, Au, and Cu.**
 - Meets required minimum pad deformation,
 - Meets stringent automotive quality requirements.
 - Technology suitable for Au flash OPM applications.
 - Stable CRES (Online Clean needed for Cu).
- **W41 ViProbe[®] enables >200°C Sort.**
- **KGD High Speed Converter testing (at Sort) is possible using ViProbe[®] Direct Attach.**



Future Work.

- Work with ITS and Feinmetall to find optimum online clean recipe (Required for Cu Pad).
- Evaluate bandwidth capabilities of ViProbe[®] Direct Attach.
- Investigate high temperature >200'C and influence of prober limitations.
- Further Over Pad Metallization (OPM) evaluations Au flash < 1μM.



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Thank You.

Questions?



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